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A. Cassinese, S. Aliasghari, R. Valizadeh, V. Palmieri

Legnaro **Thick Films**

TTC 2020, CERN 5 February 2020

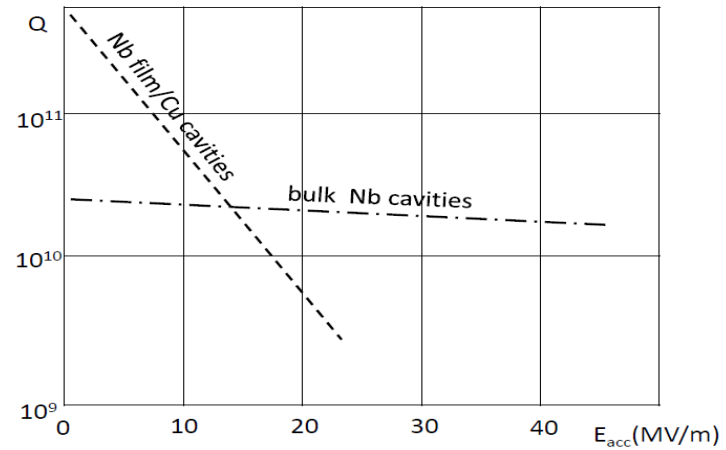
Work supported by the INFN V group experiment TEFEN
and performed under the CERN-INFN-STFC Agreement N. KE2722/BE/FCC



EASITrain – European Advanced Superconductivity Innovation and Training. This Marie Skłodowska-Curie Action (MSCA) Innovative Training Networks (ITN) has received funding from the European Union's H2020 Framework Programme under Grant Agreement no. 764879

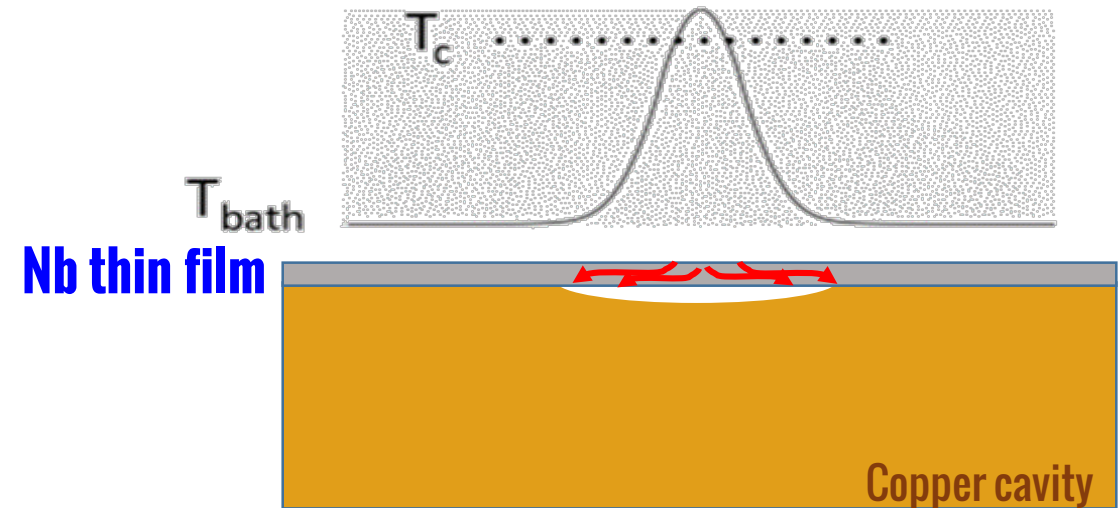
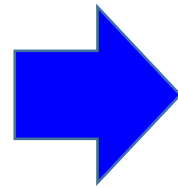
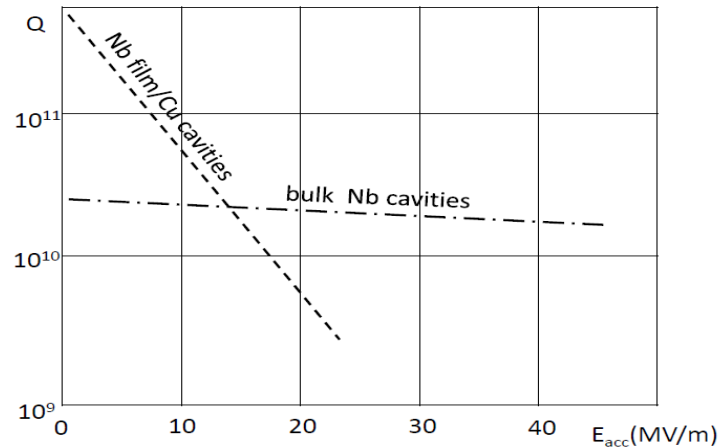
Motivation (1)

Q slope, a problem since 80's



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Q slope, a problem since 80's



- **Theoretical model from Vaglio and Palmieri**

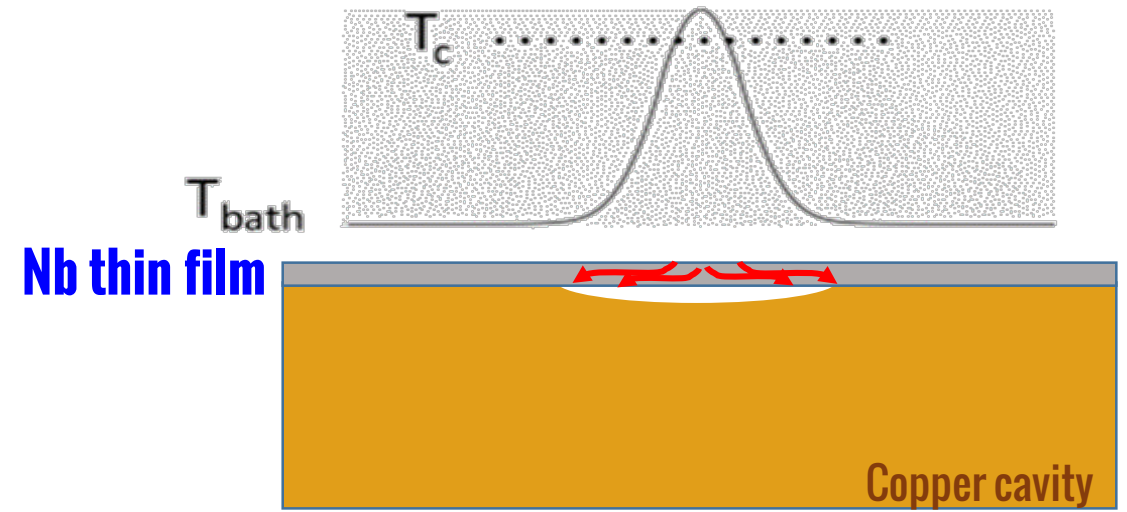
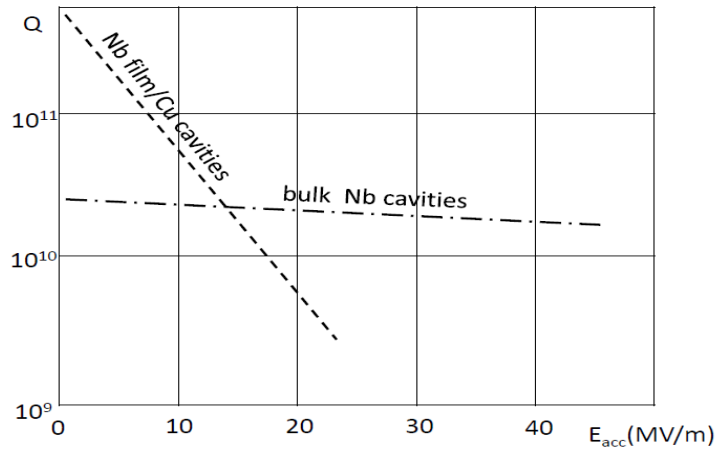
Q-slope is related to local enhancement of the **thermal boundary resistance at the Nb/Cu interface**, due to poor thermal contact between film and substrate

V. Palmieri and R. Vaglio, Supercond. Sci. Technol, Jan. 2016

- **Thick Film for hard coatings developed at LNL**

Motivation (1)

Q slope, a problem since 80's



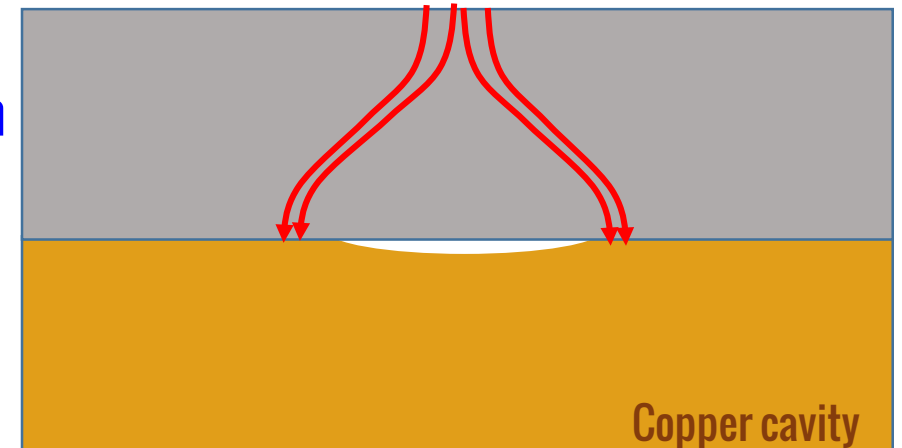
LNL IDEA

Increasing the thickness



Thermal dissipation could by-pass the thermal defect

Nb thick film

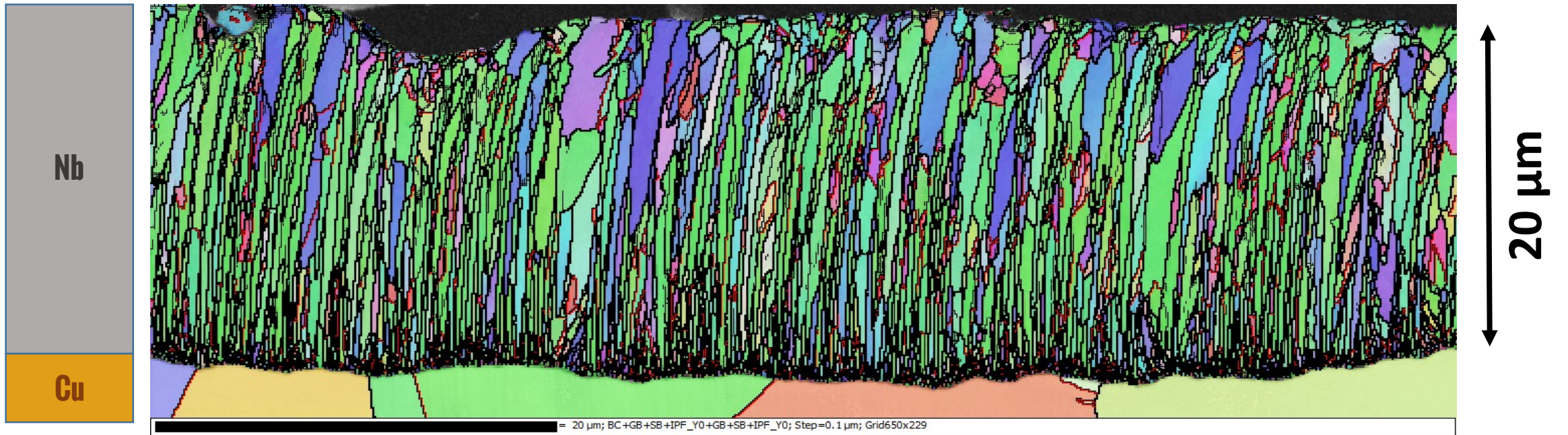


Motivation (2)

BULK LIKE PROPERTIES ON A FILM



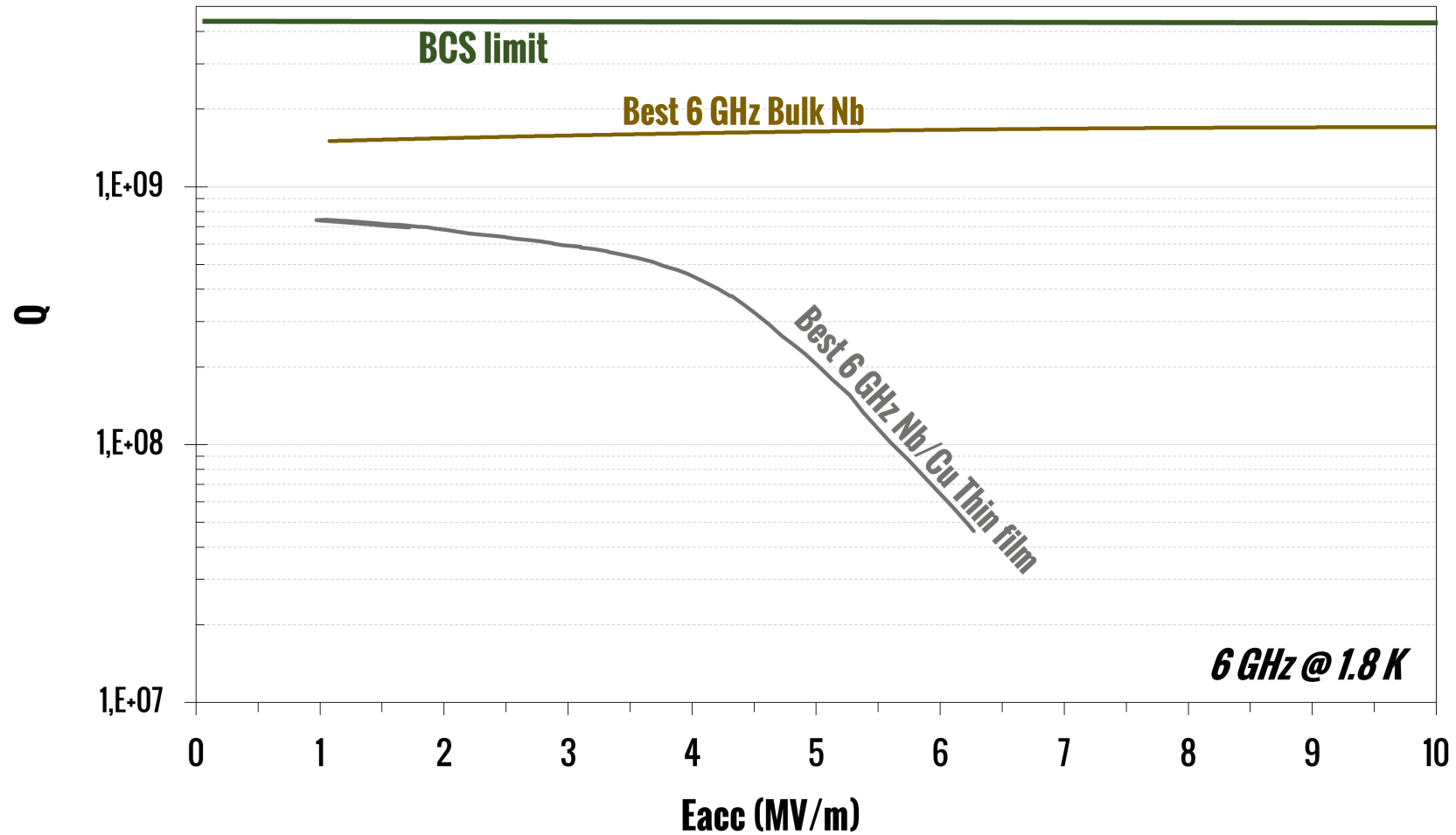
Thick films increase grain dimensions and RRR



EBSD Micrograph of cavity #4, Courtesy of Reza Valizadeh (STFC)

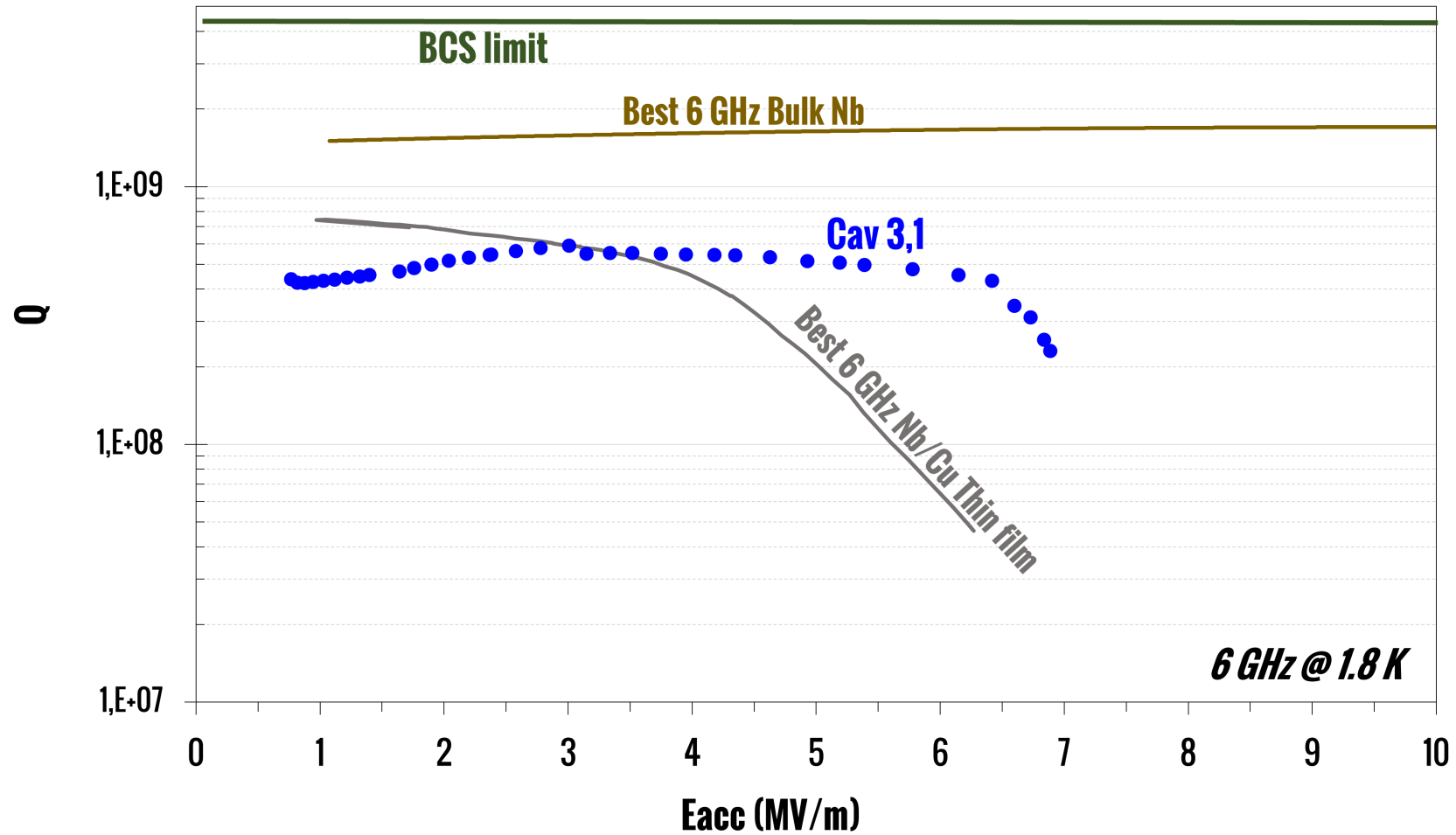
- Grain dimension $> 1 \mu\text{m}$
- RRR > 60

6 GHz Base line



First result

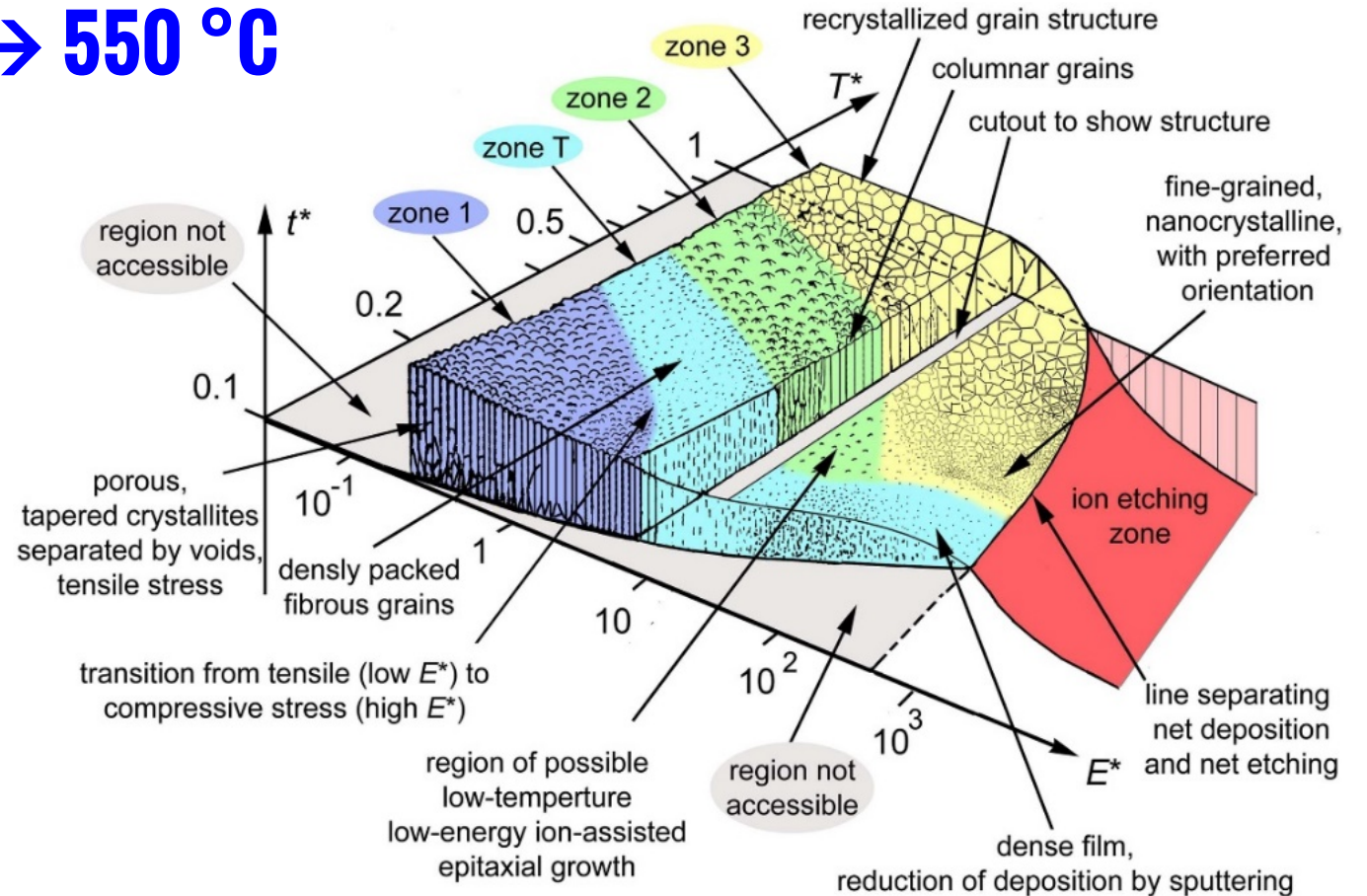
First Nb Thick Film



How to avoid peeling/increase film quality? (1)

HIGH SUBSTRATE TEMPERATURE \rightarrow 550 °C
(limited by Cu)

- Magnetron sputtering allows to play with T
- Limited access to exploration of the E axis
- Simple configuration compared to energetic condensation configurations (HiPIMS, ECR, ...)

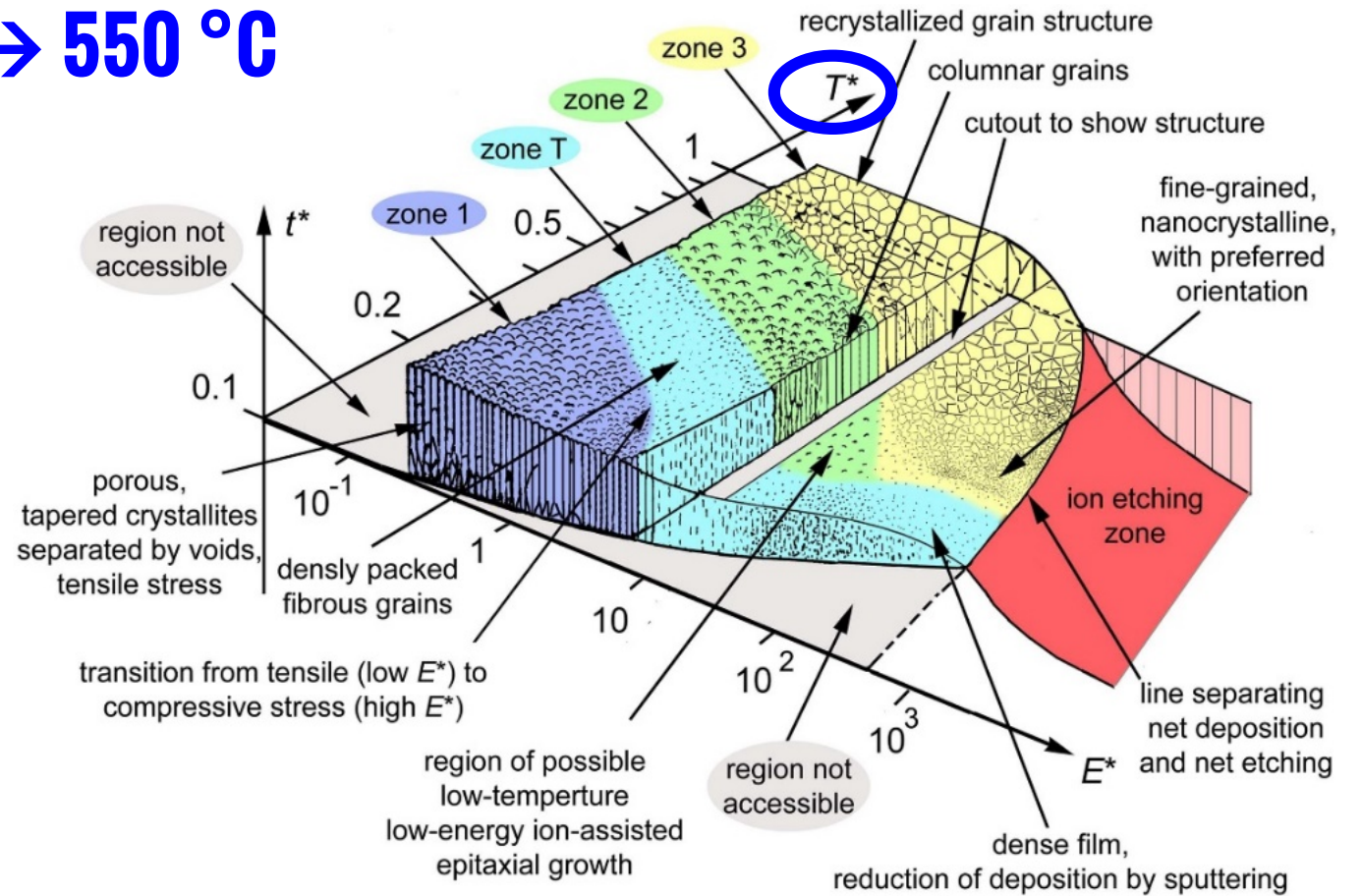


A. Anders, "A structure zone diagram including plasma-based deposition and ion etching," *Thin Solid Films*, 2010

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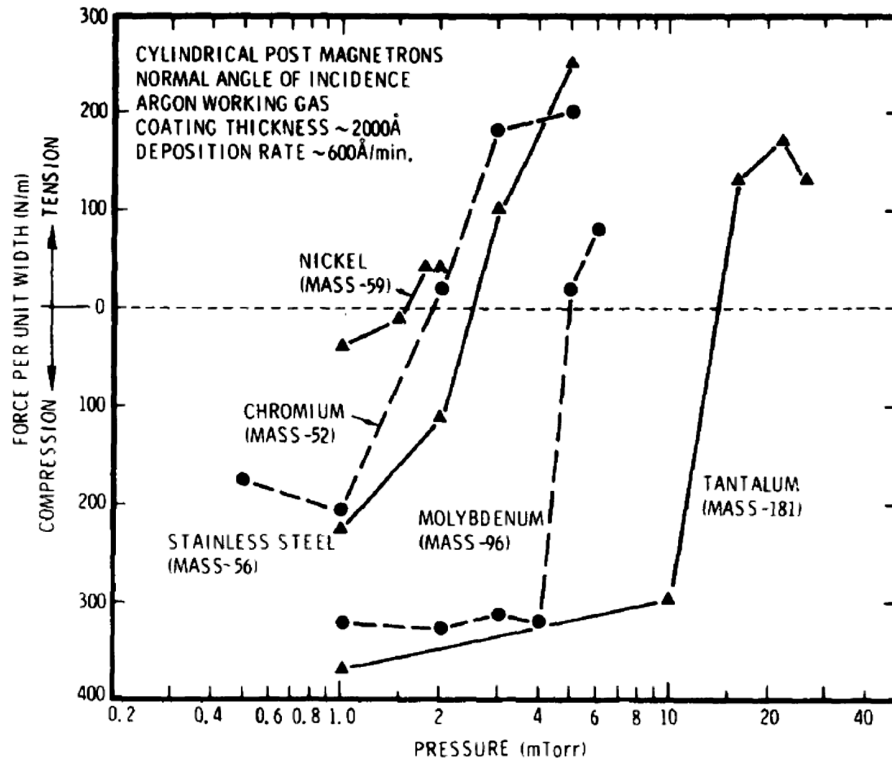
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How to avoid peeling/increase film quality? (2)

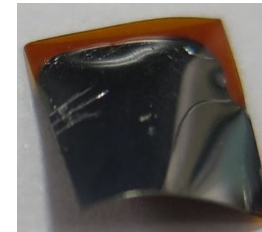
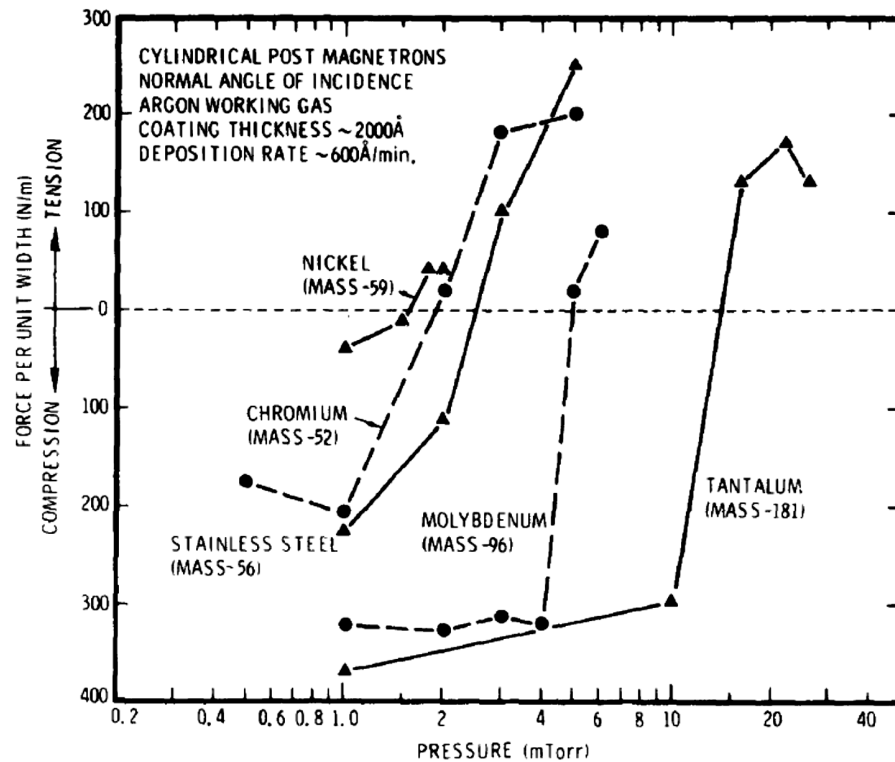
ZERO STRESS PRESSURE



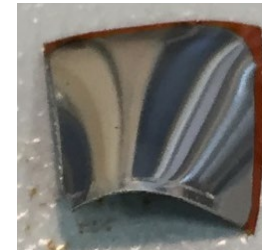
J. A. Thornton and D. W. Hoffman, "Stress-related effects in thin films," *Thin Solid Films*, 1989

How to avoid peeling/increase film quality? (2)

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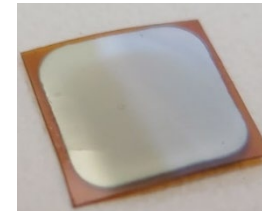
$7 \cdot 10^{-3}$ mbar



$9 \cdot 10^{-3}$ mbar



$2 \cdot 10^{-2}$ mbar

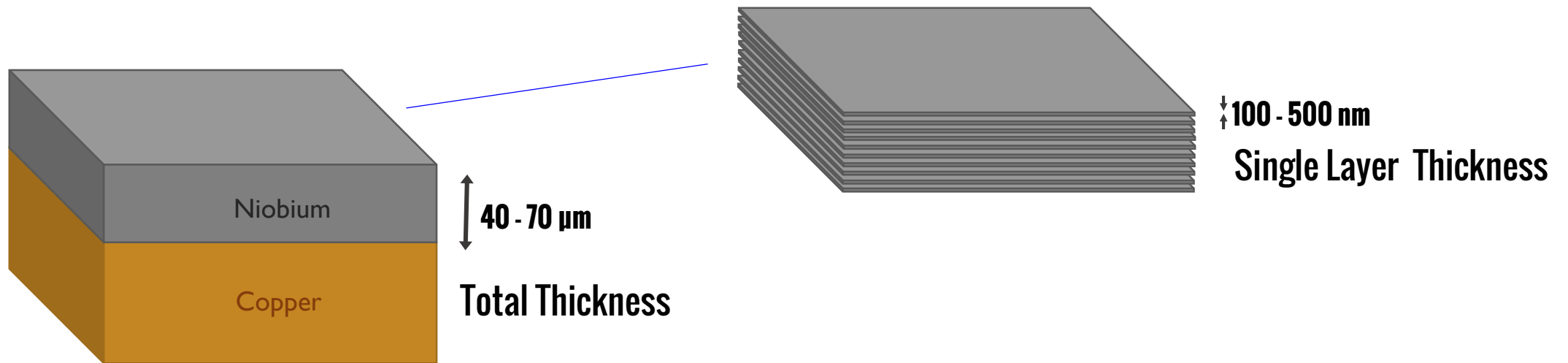
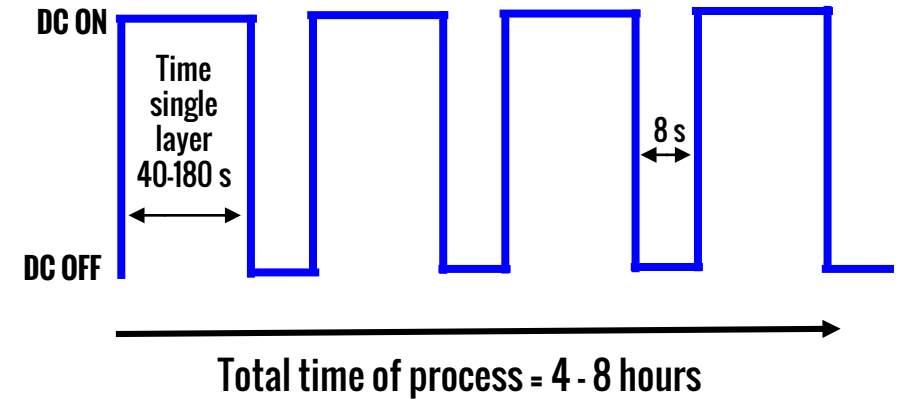


$5 \cdot 10^{-2}$ mbar

J. A. Thornton and D. W. Hoffman, "Stress-related effects in thin films," *Thin Solid Films*, 1989

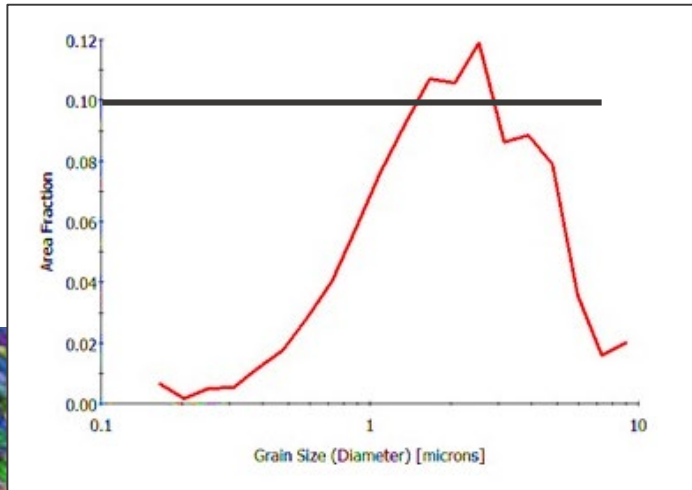
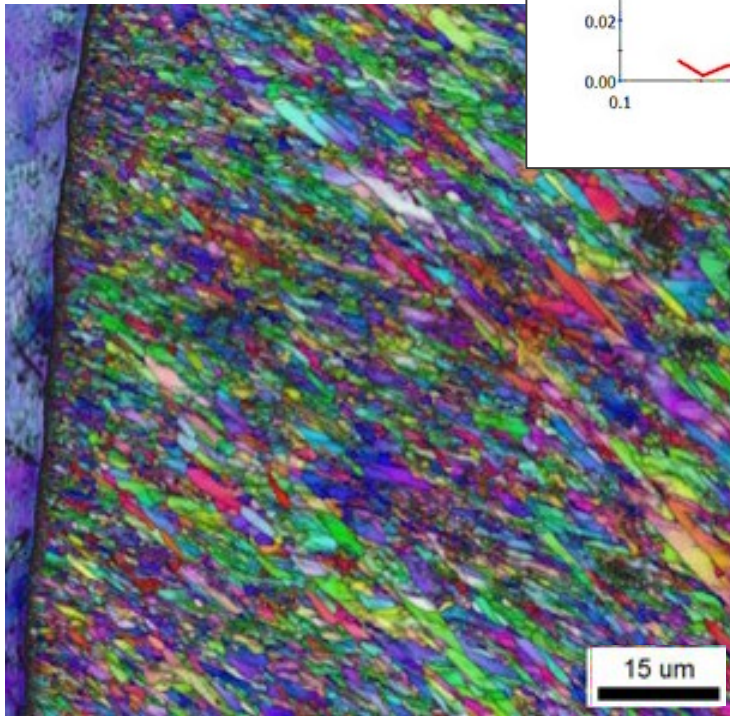
How to avoid peeling/increase film quality? (3)

LONG PULSE DEPOSITION MODE (borrowed from QWR coating procedure)



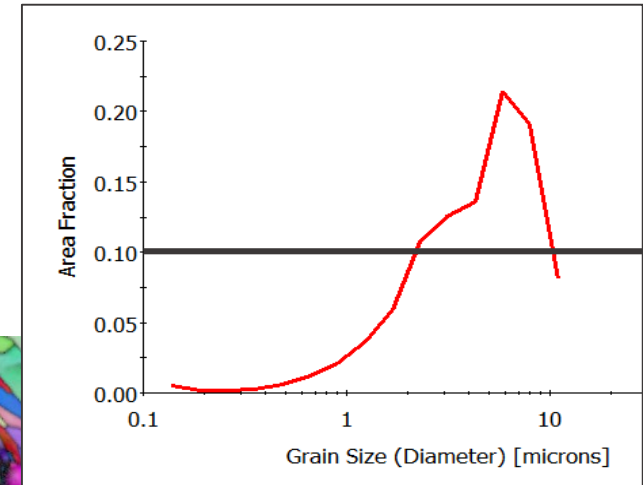
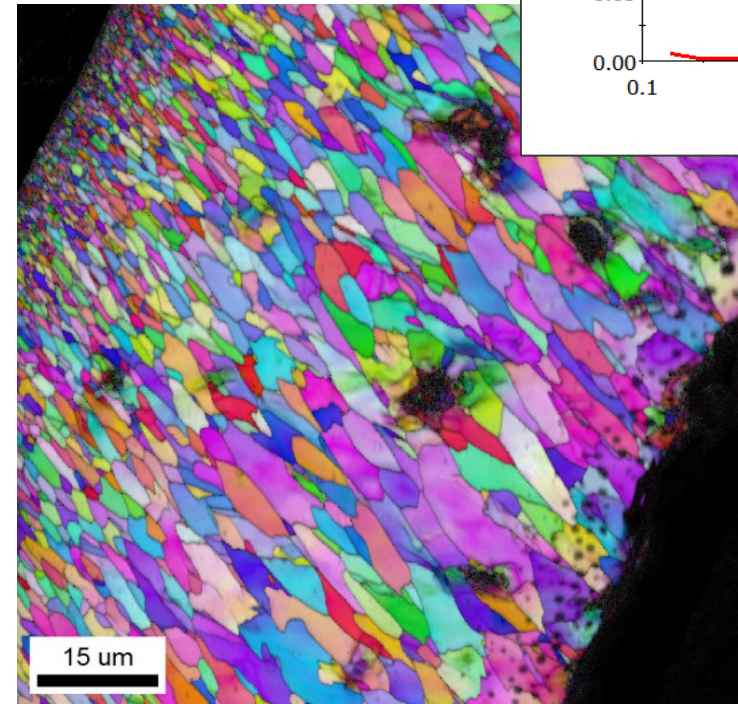
How to avoid peeling/increase film quality? (3)

one shot deposition



Cav 7, 100 μm single shot

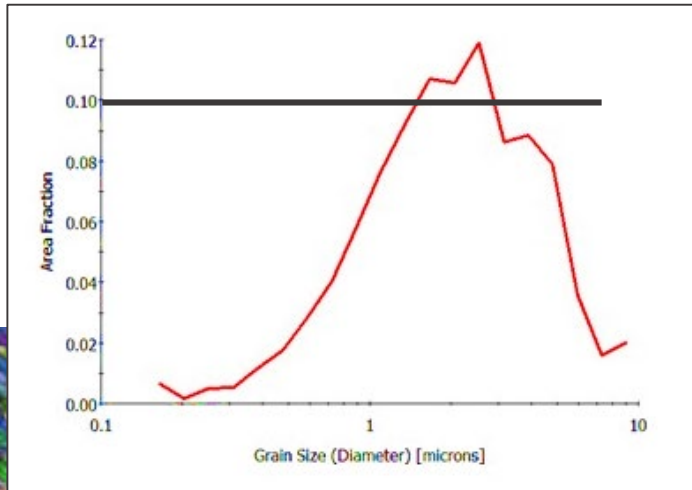
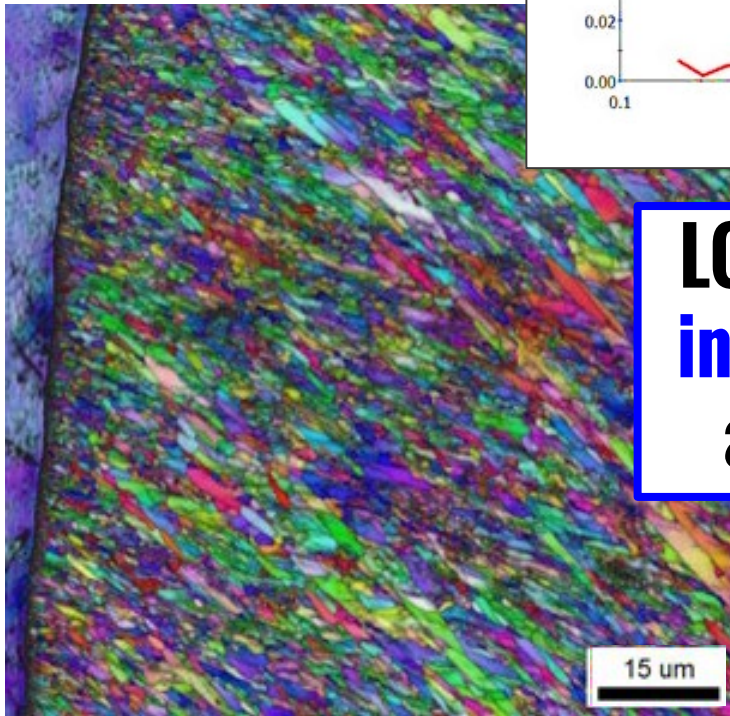
long pulse deposition



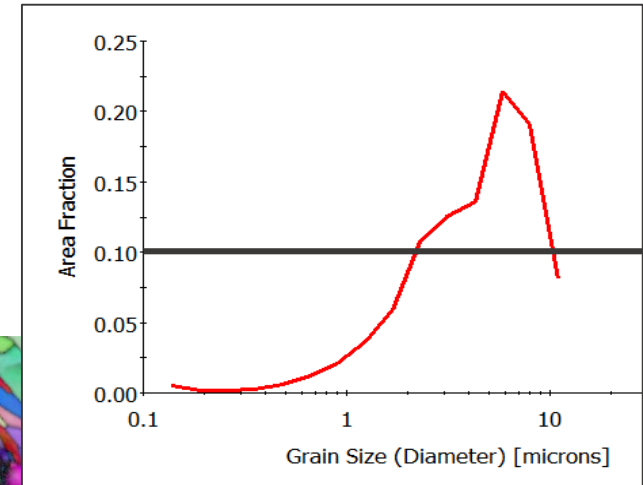
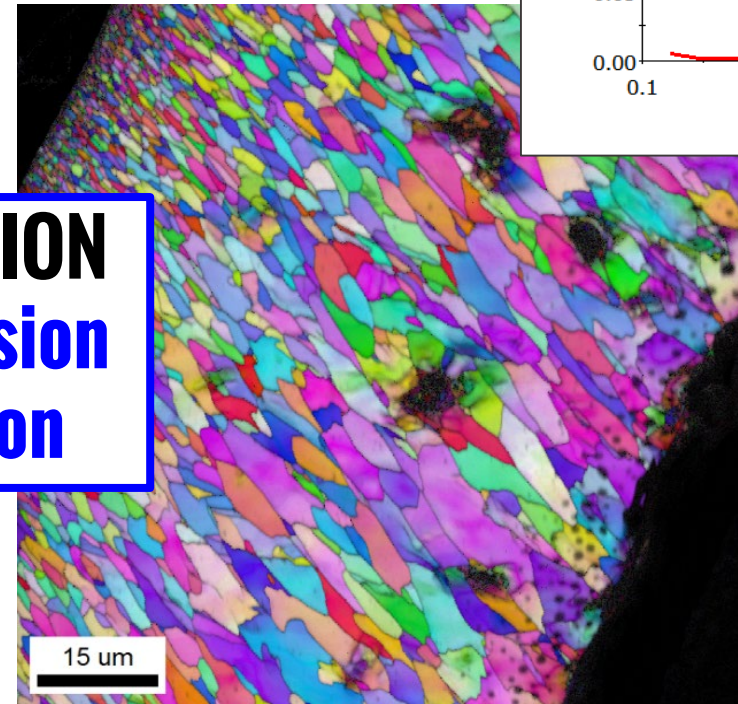
Cav 16, 75 μm thick, 500nm single pulse layer thickness

How to avoid peeling/increase film quality? (3)

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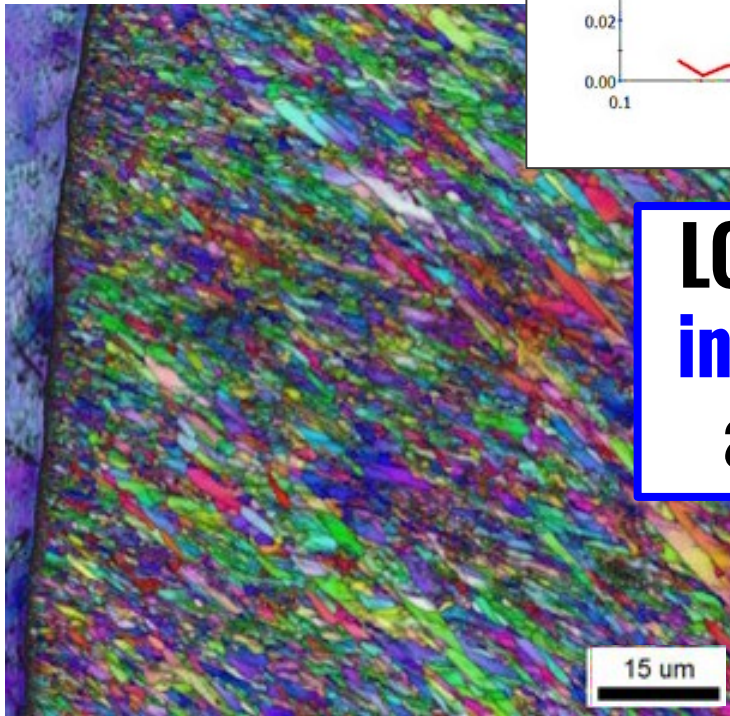
LONG PULSE DEPOSITION
increase grain dimension
and reduce dispersion

Cav 7, 100 μm single shot

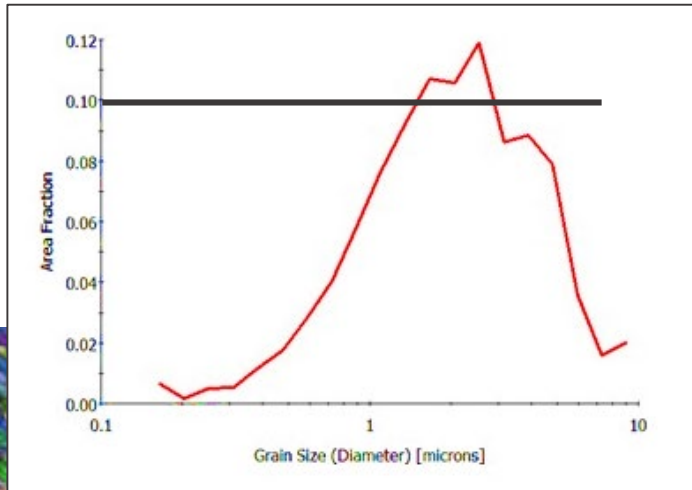
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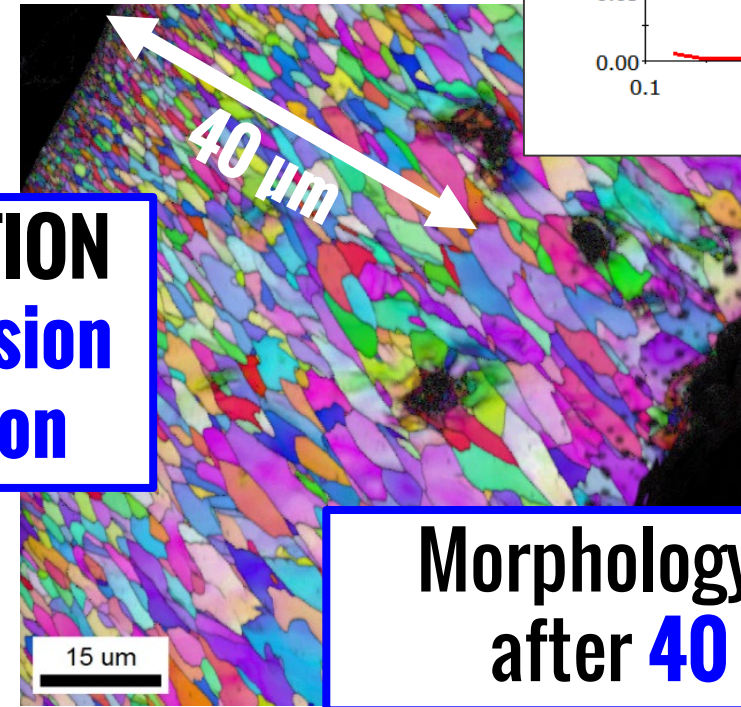
one shot deposition



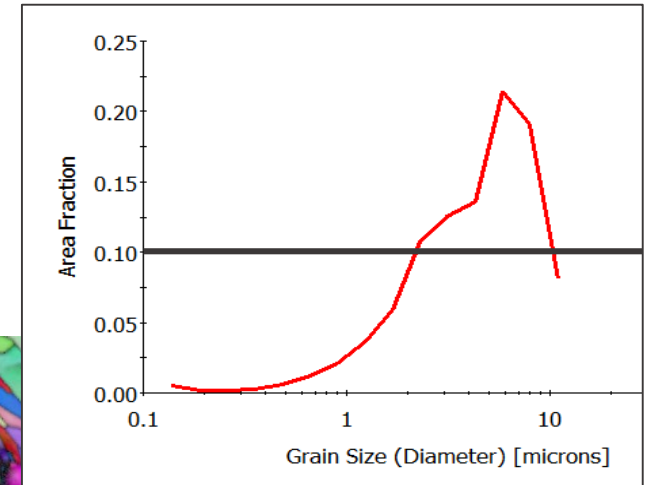
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long pulse deposition



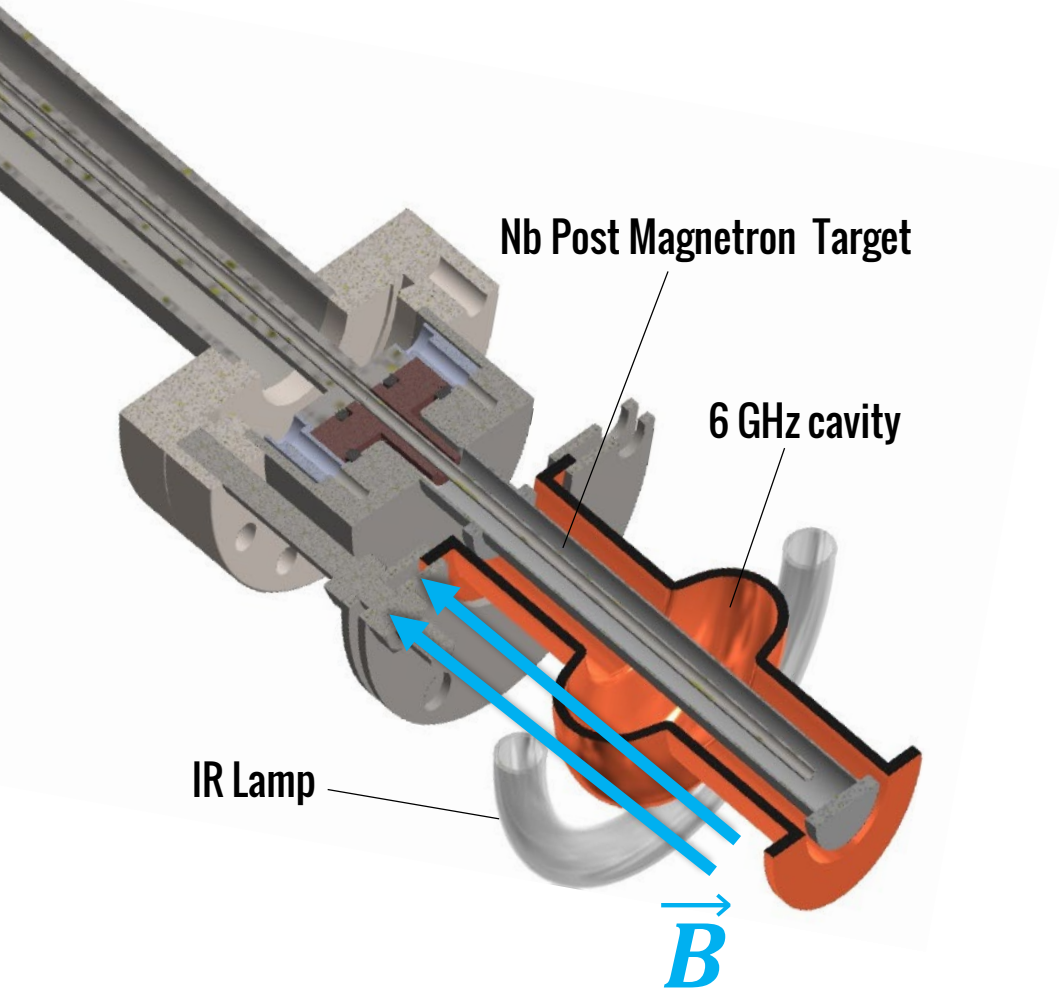
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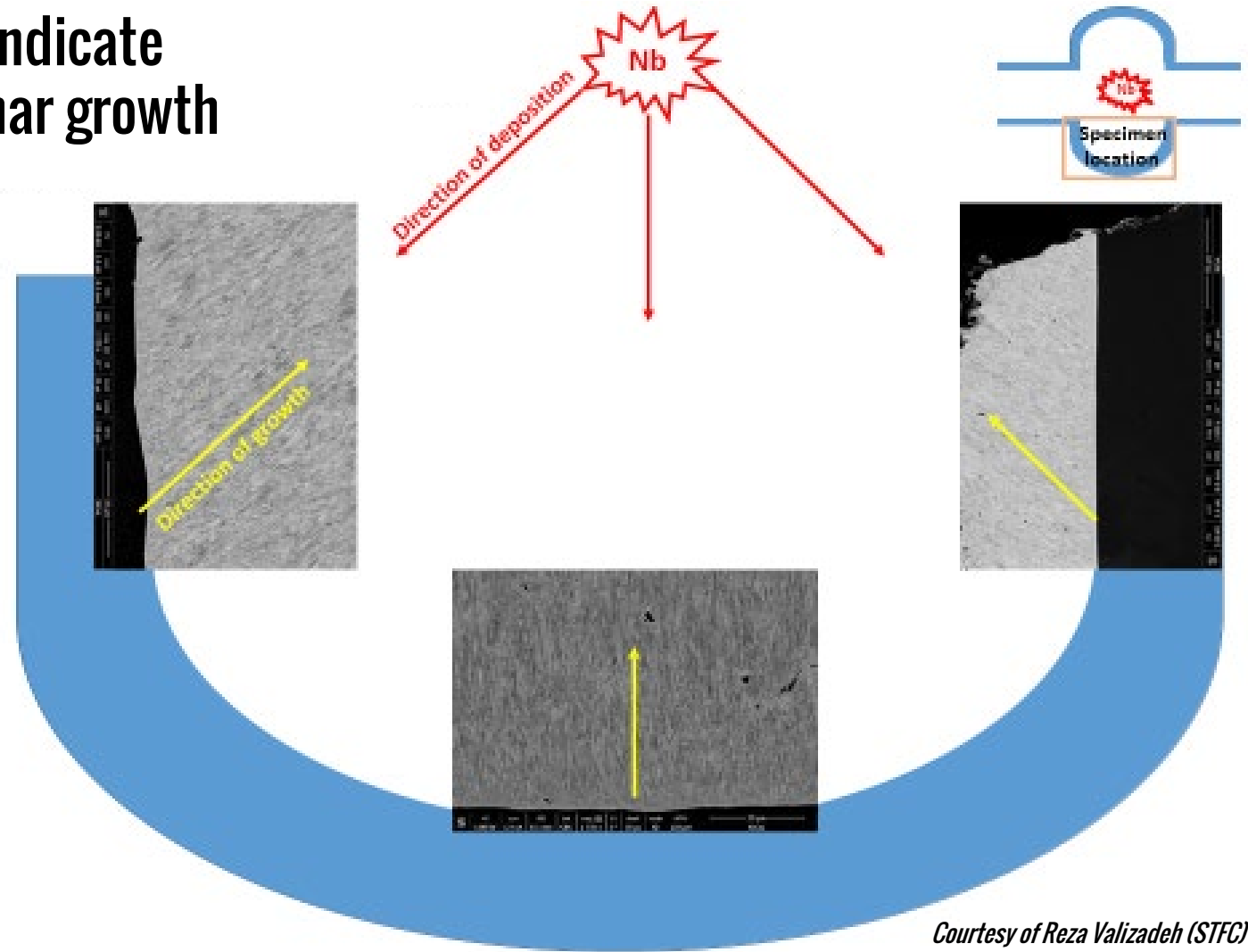
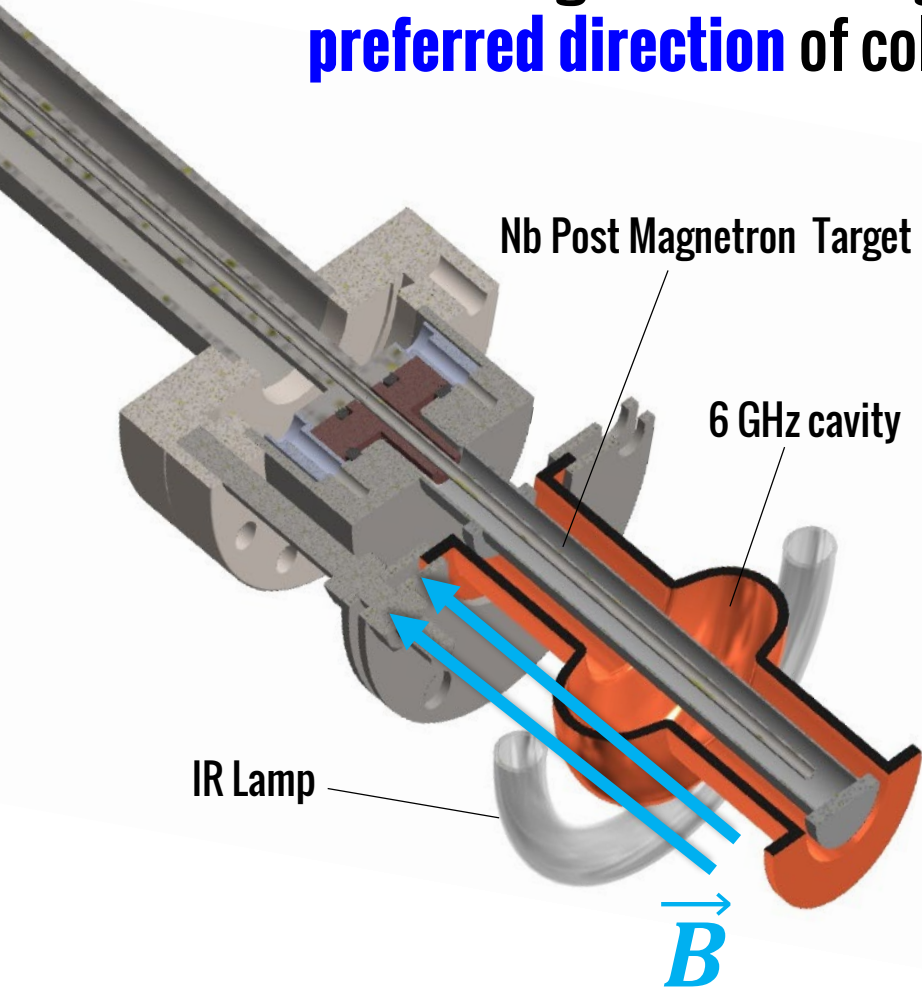
Morphology stabilizes
after **40 microns**

Thick Films Morphology



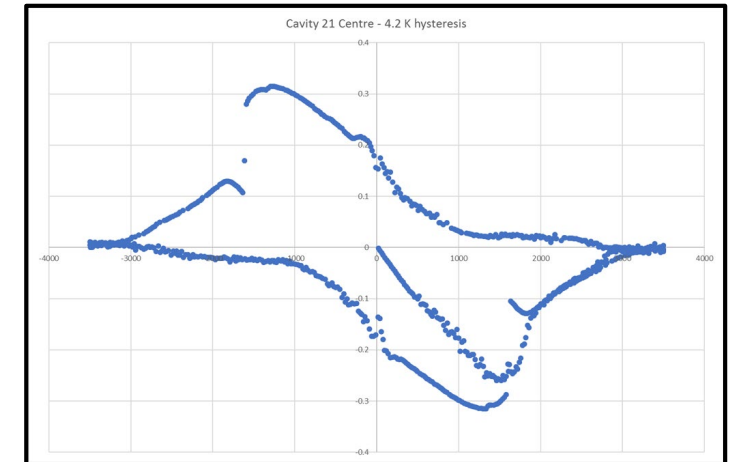
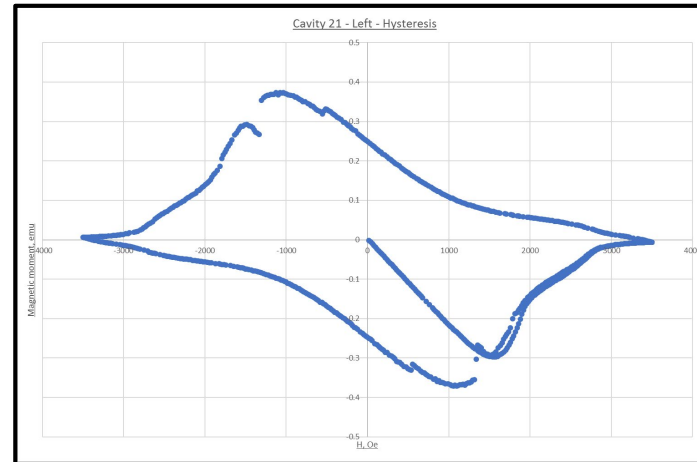
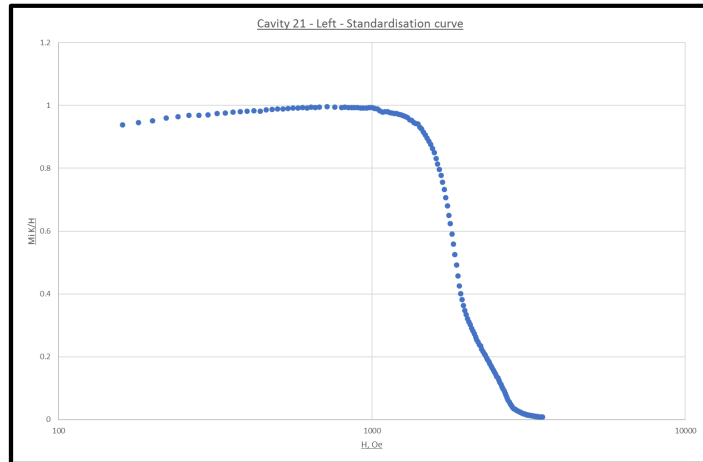
Thick Films Morphology

Channeling contrast images indicate **preferred direction** of columnar growth



Courtesy of Reza Valizadeh (STFC)

Thick Films DC Properties



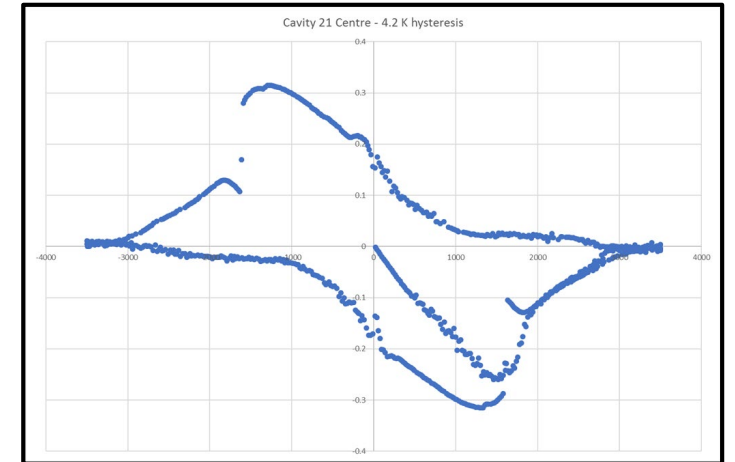
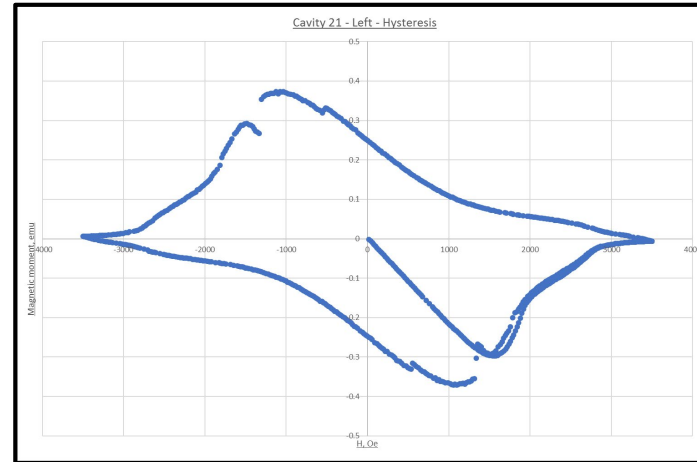
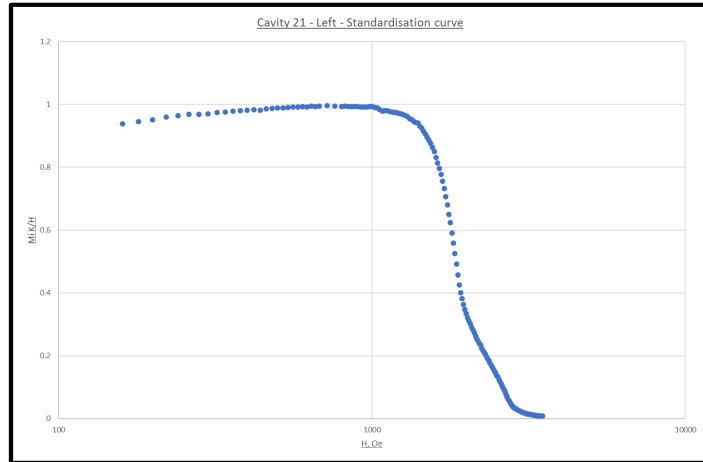
4 cavities characterized. All measurements was done on **stripped Nb film on Kapton tape @ 4,2 K**
Courtesy of Reza Valizadeh (STFC)

Nb thin films (ARIES samples)	
H_{fp}	12-20 mT
H_{c2}	280-300 mT

Courtesy of Eugen Seiler (IEE Bratislava)

Nb thick films	
H_{fp}	140-155 mT
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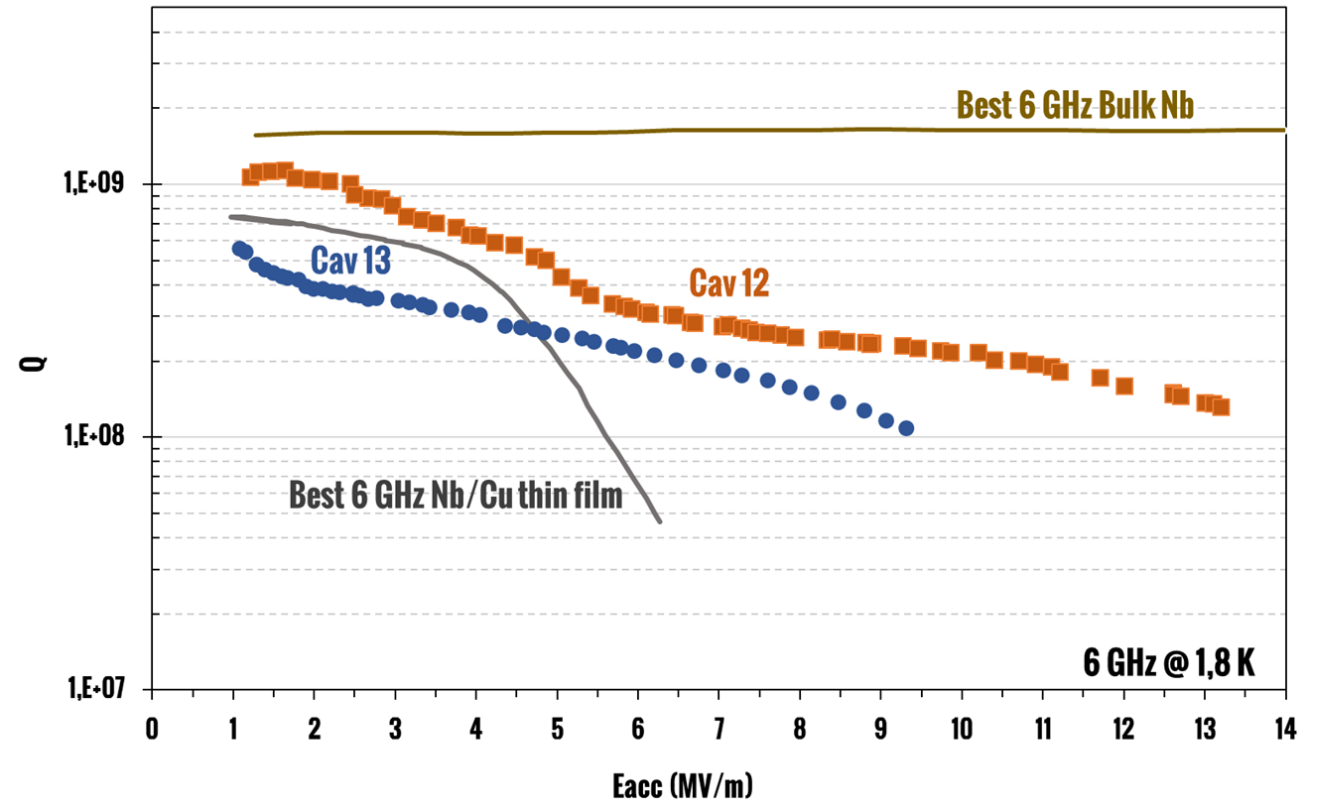
Nb thick films	
H_{fp}	140-155 mT
H_{c2}	320-350 mT

- **High H_{fp} value** between (140-155 mT)
- All films shown almost identical superconducting behavior in DC magnetometer @ 4.2 K → **No correlation with RF behavior**

Thick Films RF Results

- 30 cavities coated with thick films exploring different parameters

- Q-slope still remain in many cavities...

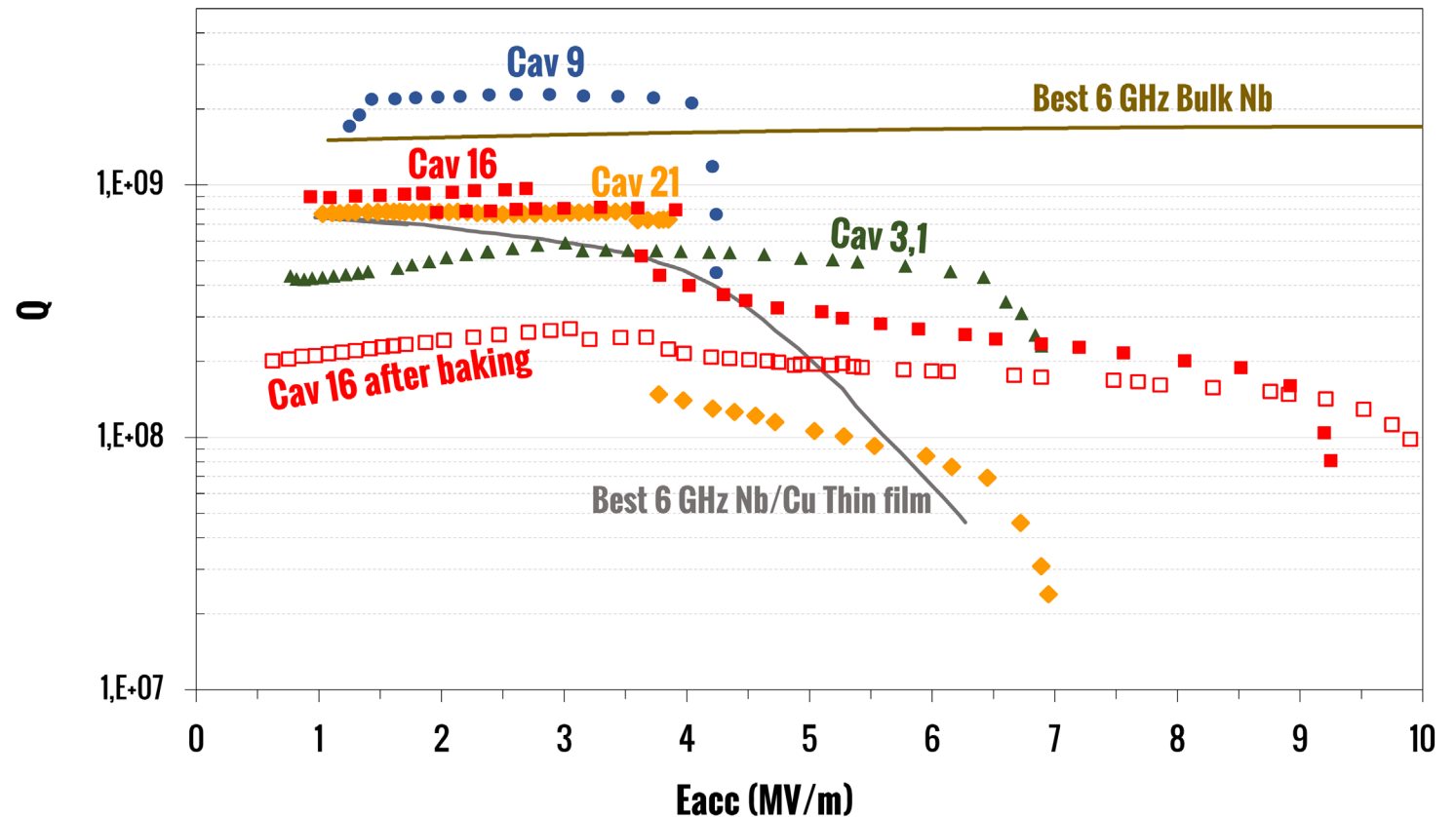


Thick Films RF Results

- 30 cavities coated with thick films exploring different parameters

- Q-slope still remain in many cavities...

- ...but not in all!

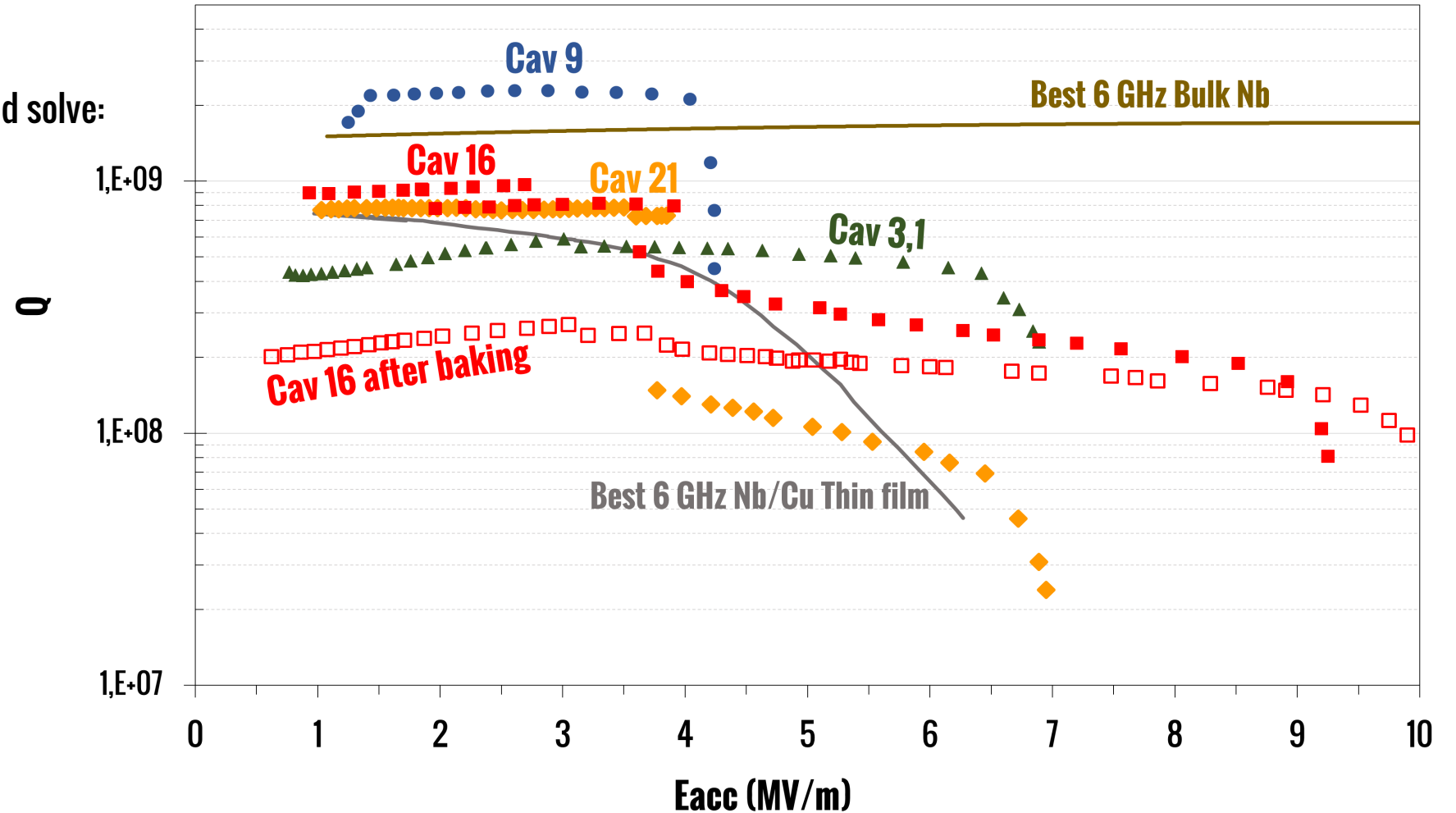


Thick Films RF Results

- **Great results**

but still remain to understand and solve:

- **Reproducibility issue**
- **Q-switch @ 4 MV/m**



Thick Films RF Results

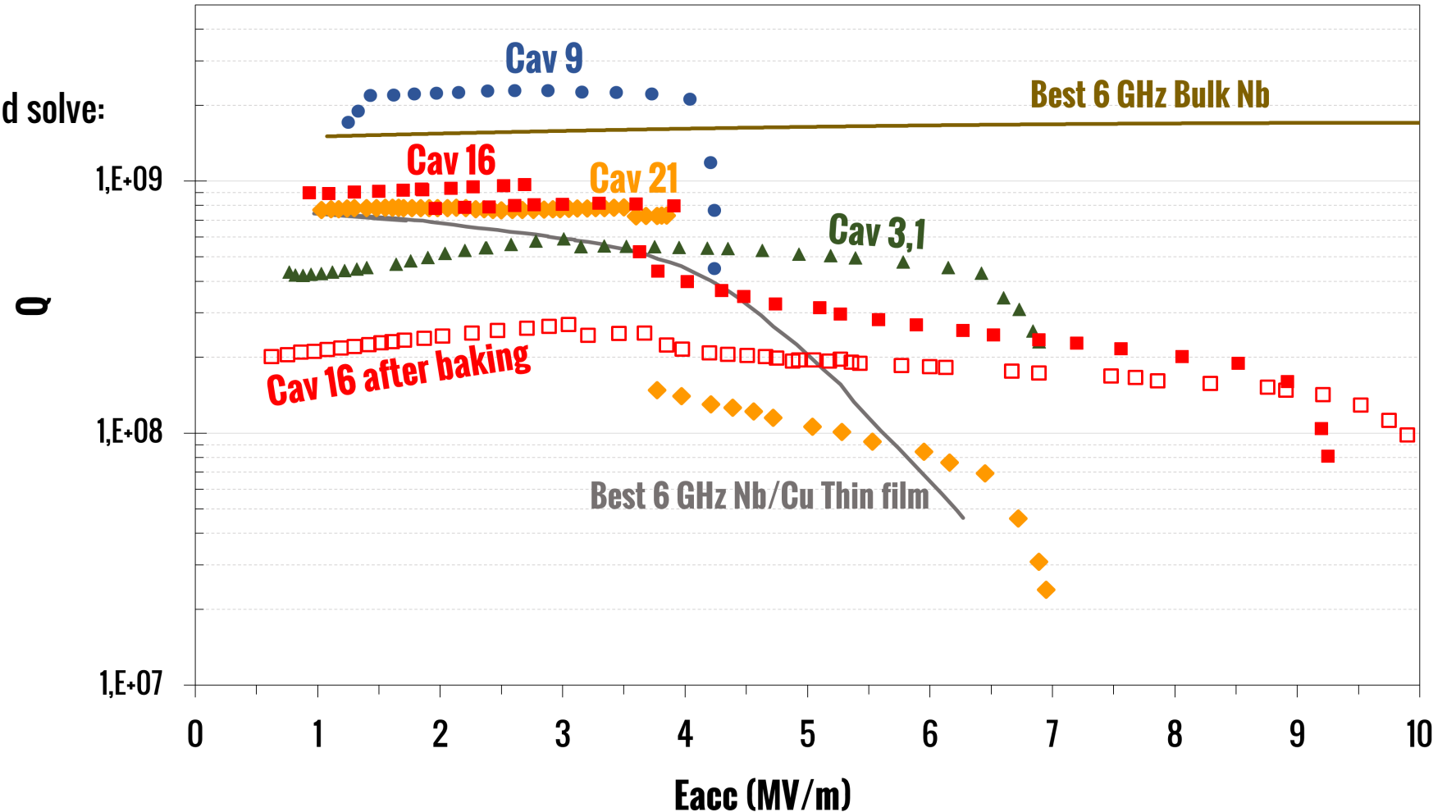
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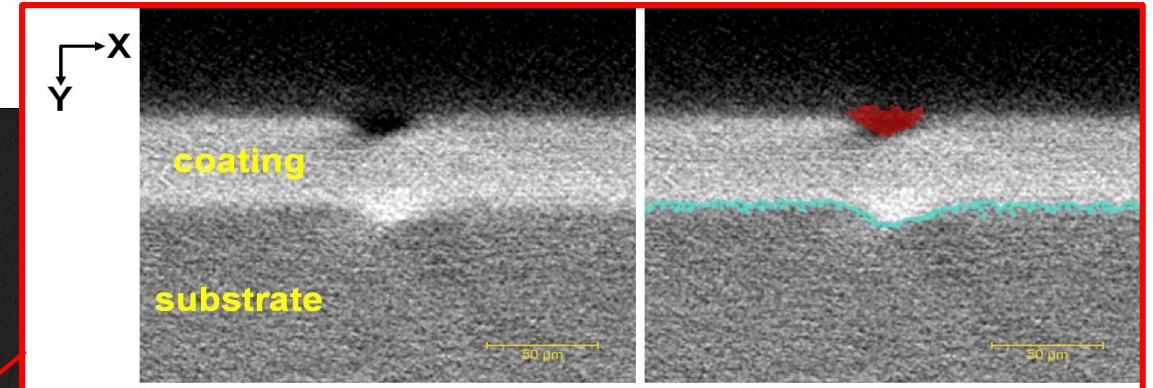
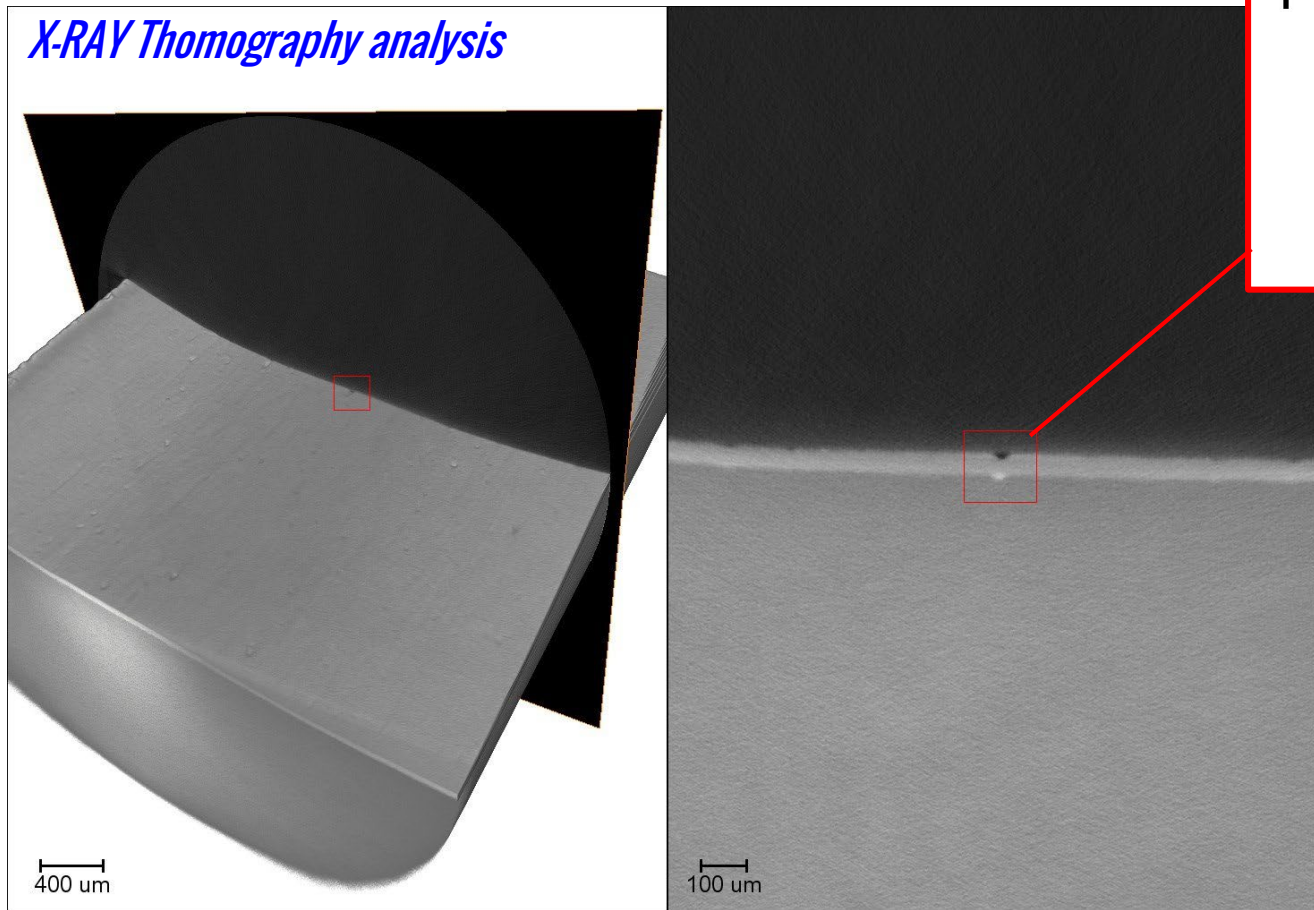
- **Reproducibility issue**
- **Q-switch @ 4 MV/m**



- **Substrate effect?**



Possible explanation low reproducibility → Substrate defects

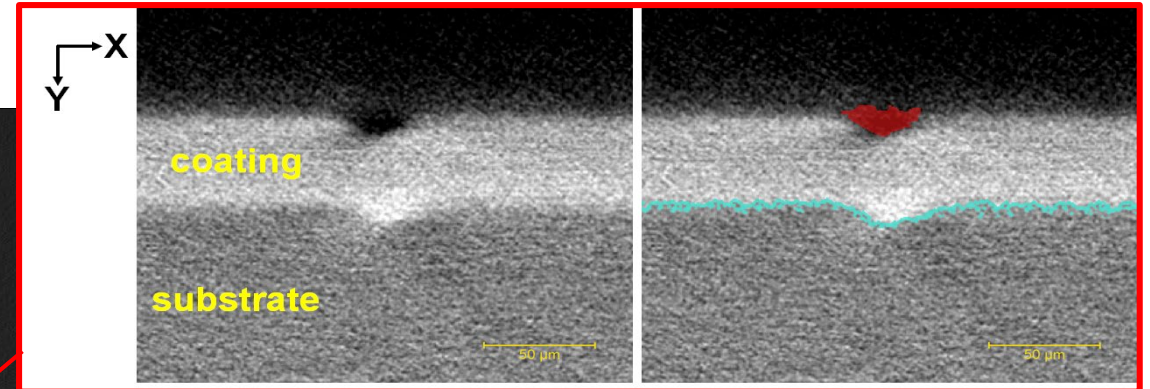
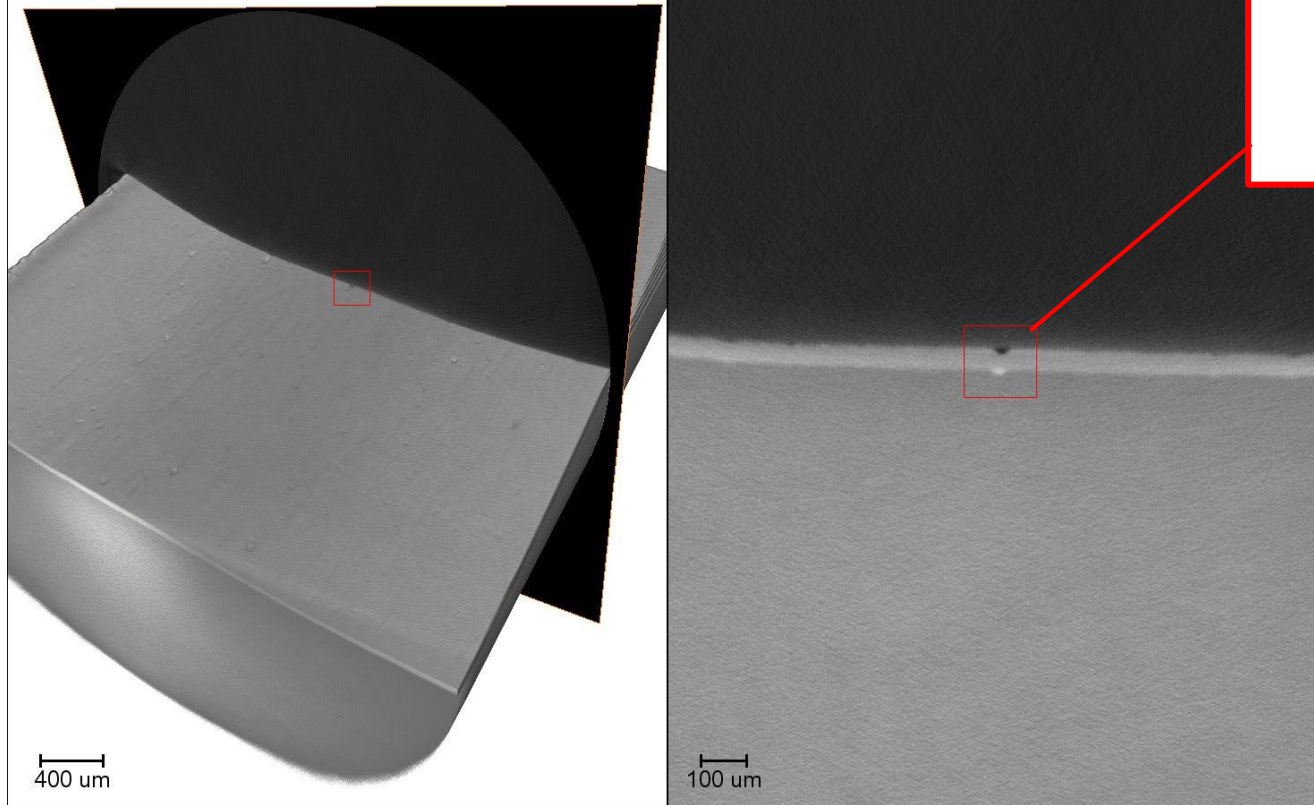


X-RAY Thomography virtual cross-section

Paper submitted, courtesy of Sepideh Aliasghari (University of Manchester)

Possible explanation low reproducibility → Substrate defects

X-RAY Thomography analysis



X-RAY Thomography virtual cross-section



EDS of a FIB cross-section sample

Paper submitted, courtesy of Sepideh Aliasghari (University of Manchester)

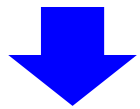
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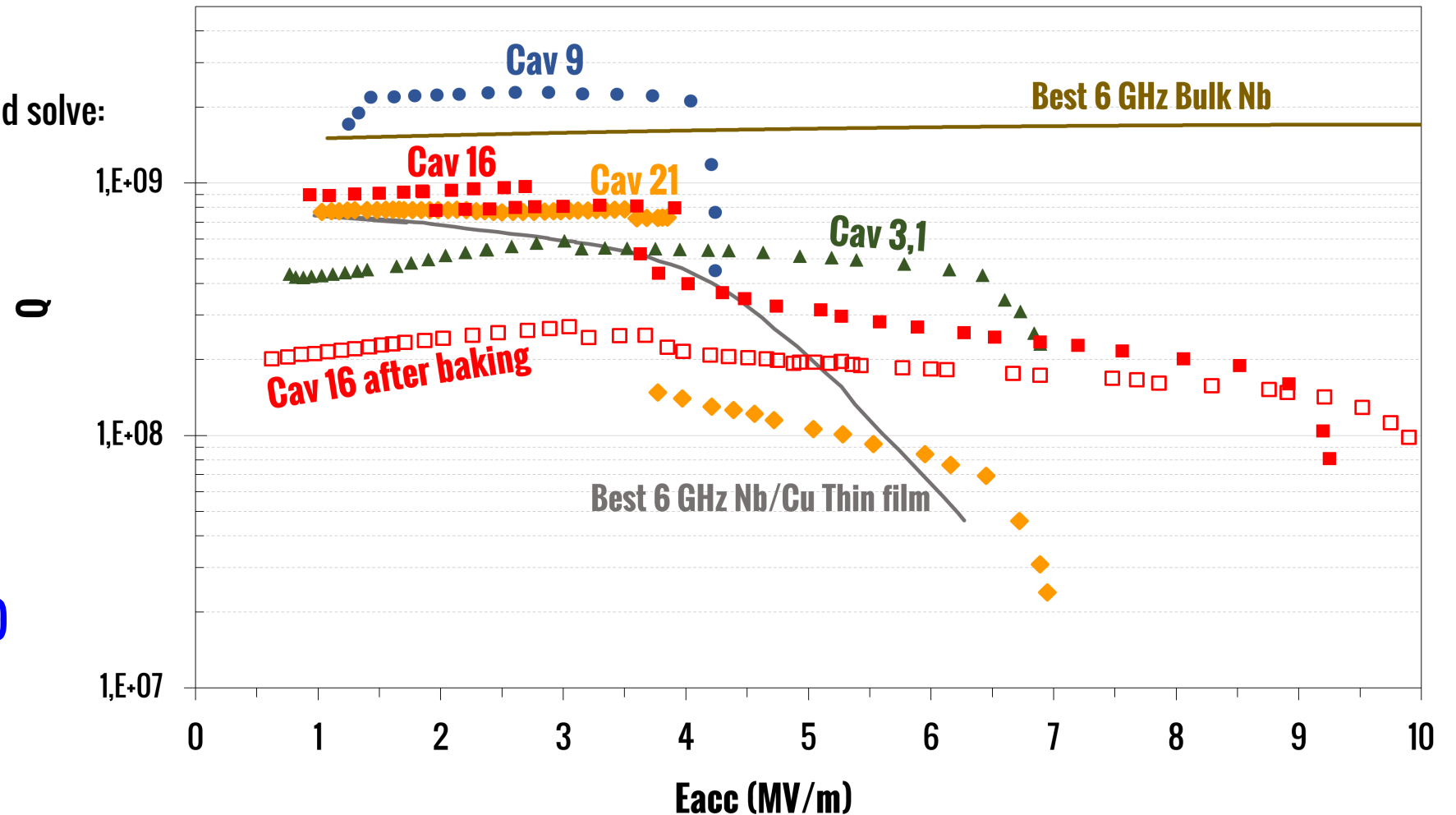
- **Reproducibility issue**

- **Q-switch @ 4 MV/m**



- **Substrate effect?**

- **Hot leaks (10^{-11} mbar*I/s)**

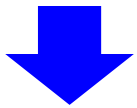


Thick Films RF Results

- **Great results**

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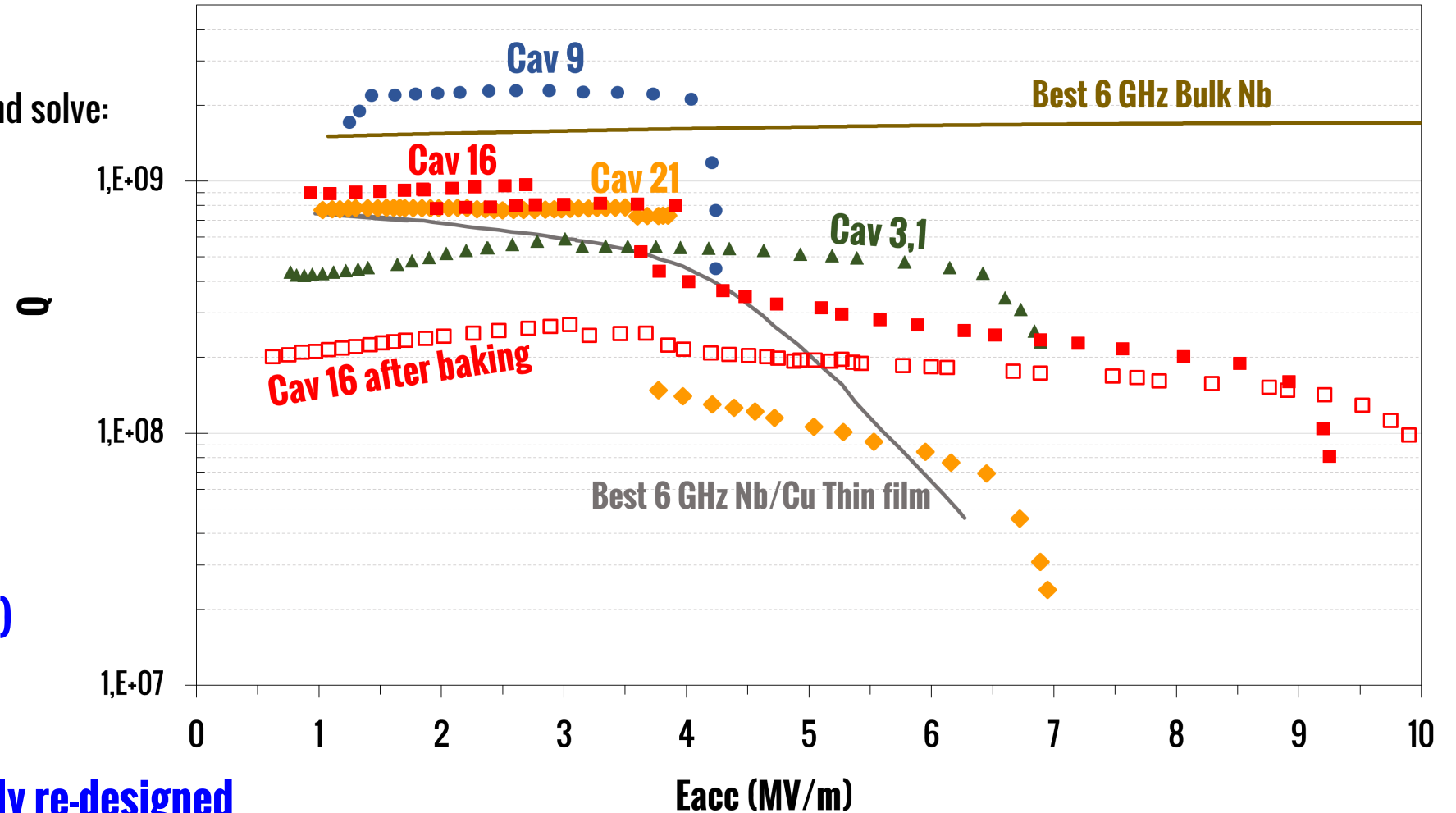
- **Reproducibility issue**
- **Q-switch @ 4 MV/m**



- **Substrate effect?**
- **Hot leaks (<math> < 10^{-11}</math> mbar*l/s)**



Magnetron source completely re-designed



Conclusions

- **Q-slope mitigation** possible with thick films
- **Low reproducibility and low accelerating gradient**
 - Substrate defects → Vibrotumbling (see TTC2019)
 - Hot leaks → magnetron source re-designed
- **New results soon**

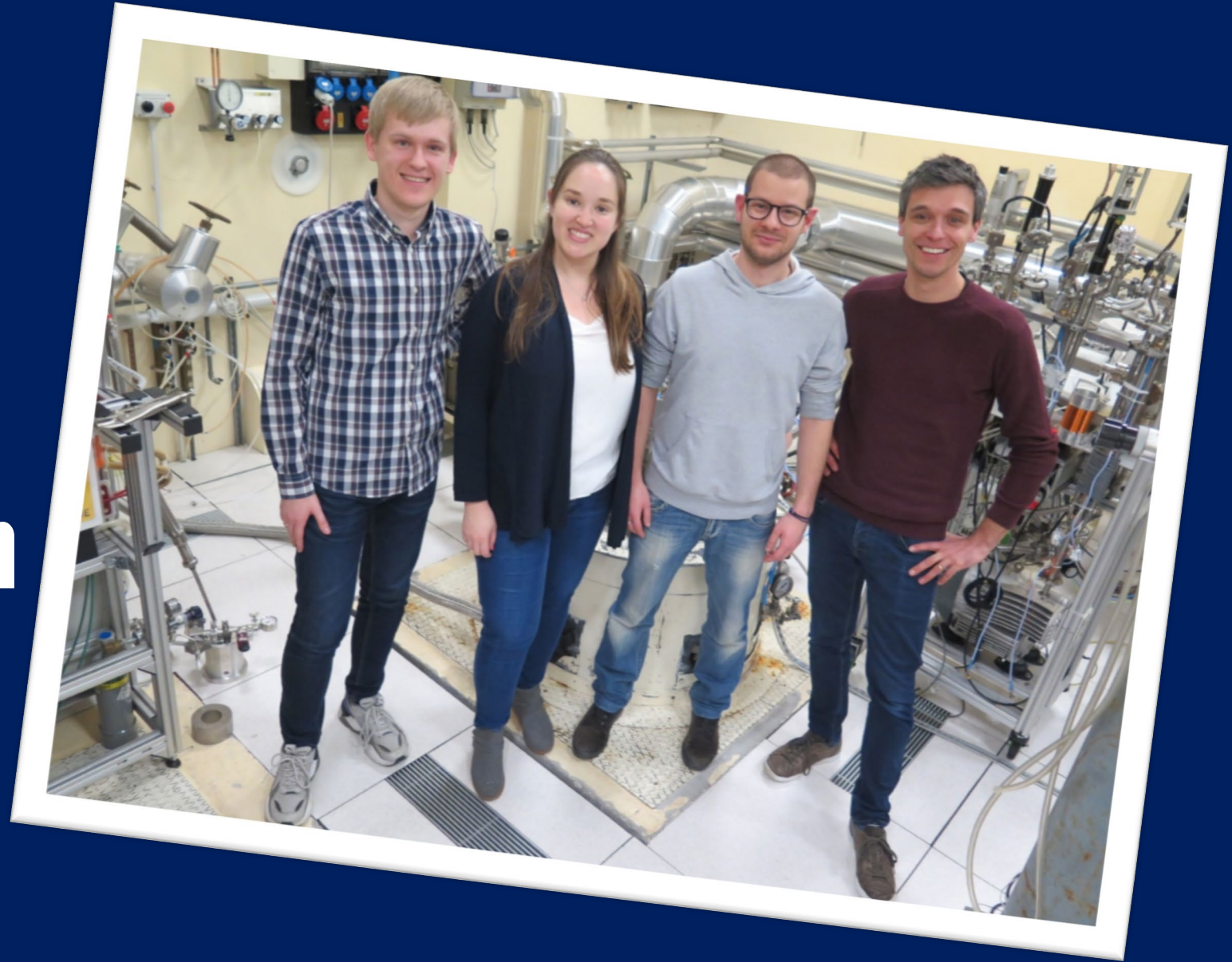
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- **New results soon**

and future work

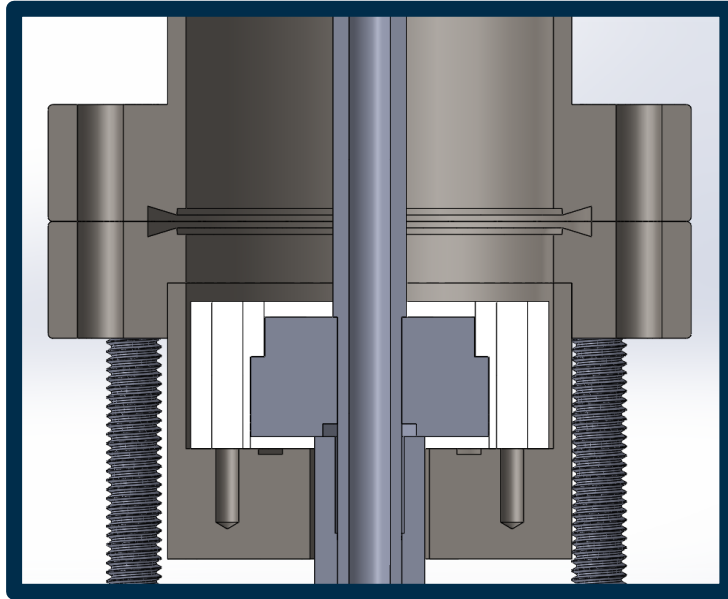
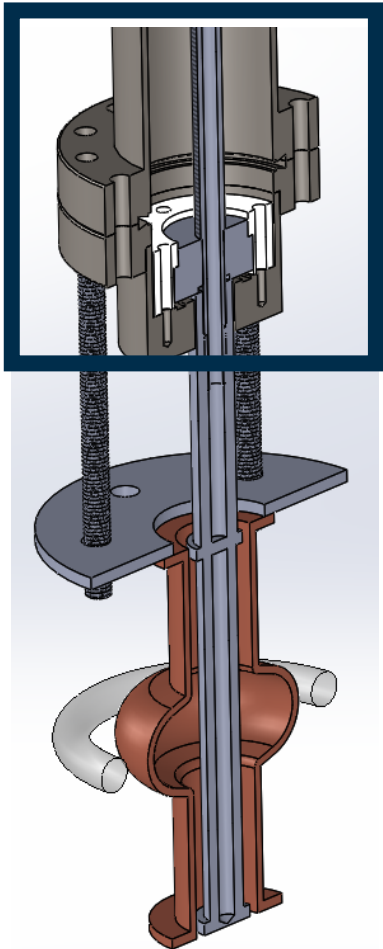
- Continue study on 6 GHz
- QPR samples
- 6 GHz → 1.3 GHz

**Thank you
for your attention**



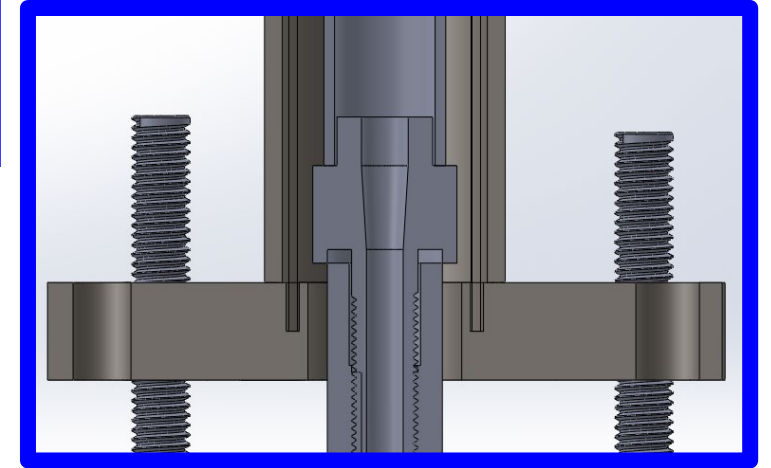
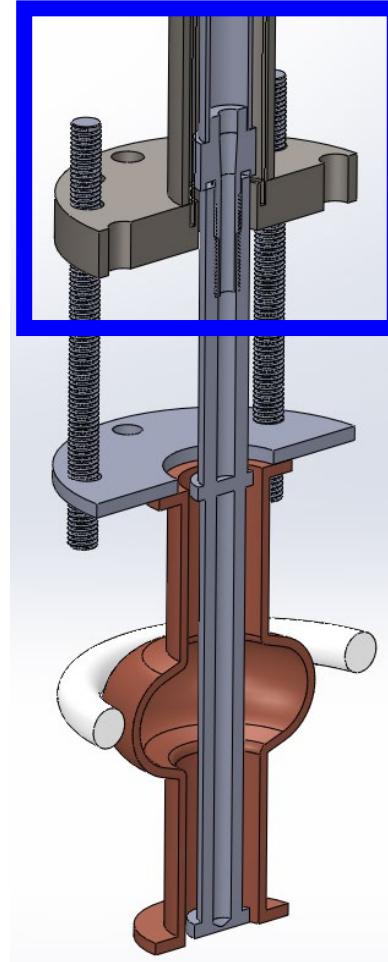
New magnetron configuration

Old



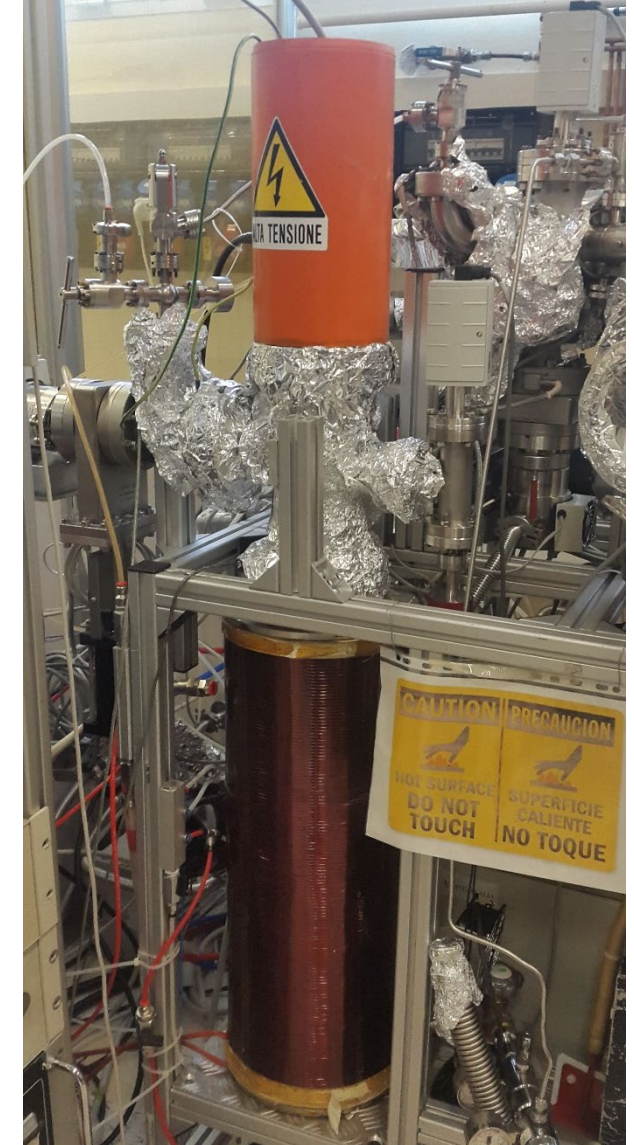
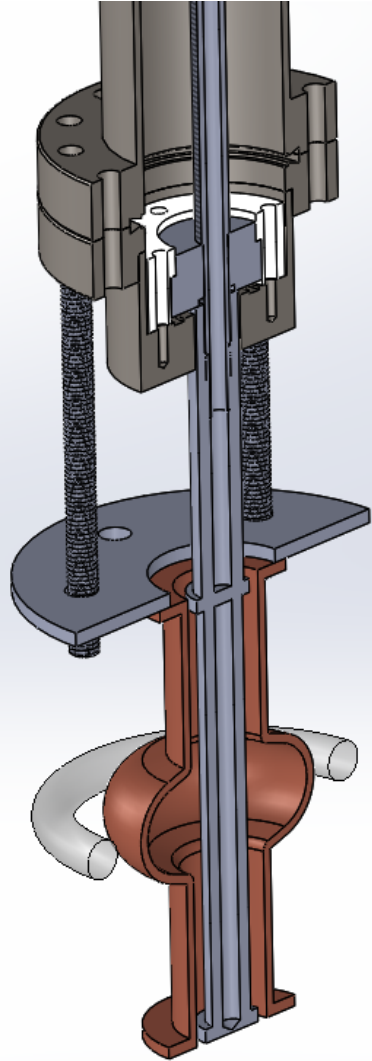
**1 Copper gasket
2 Viton o-rings**

New

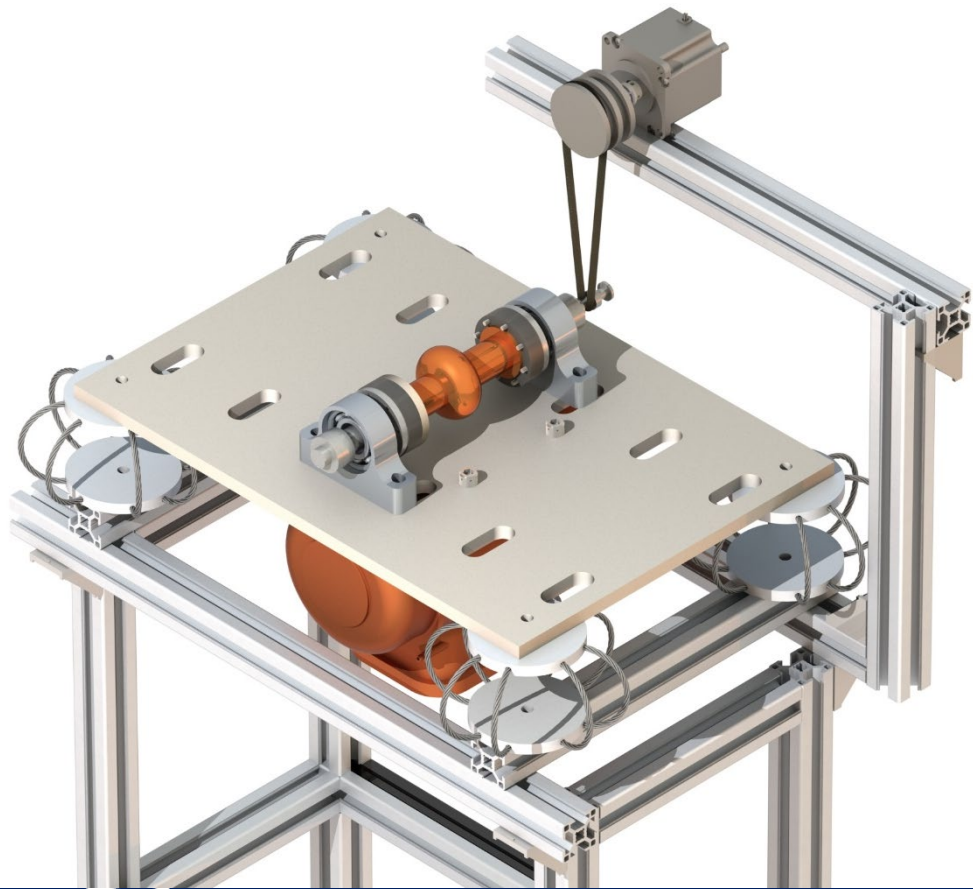


1 Viton o-ring

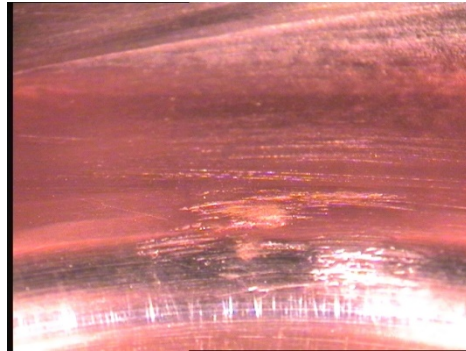
Coating Set-up



Vibrotumbling



Initial surface



Step 1

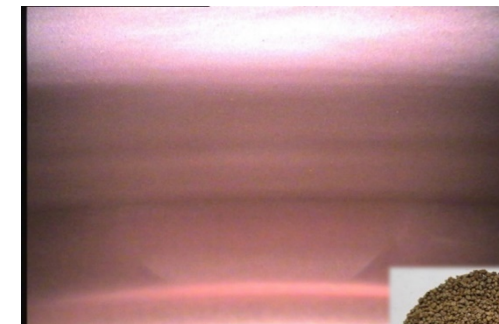


0,3 g/h
3,6 $\mu\text{m/h}$

Al_2O_3



Step 2

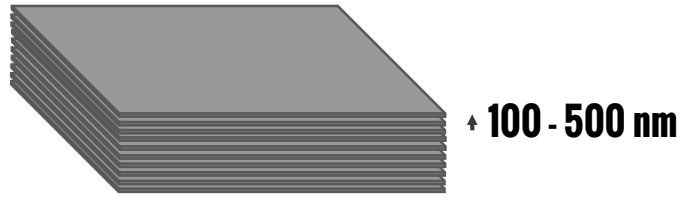


0,01 g/h
0,1 $\mu\text{m/h}$

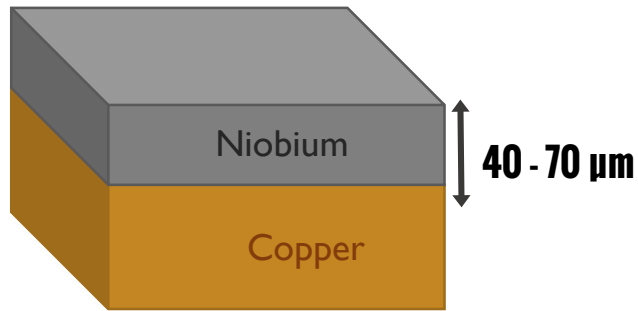
Coconut



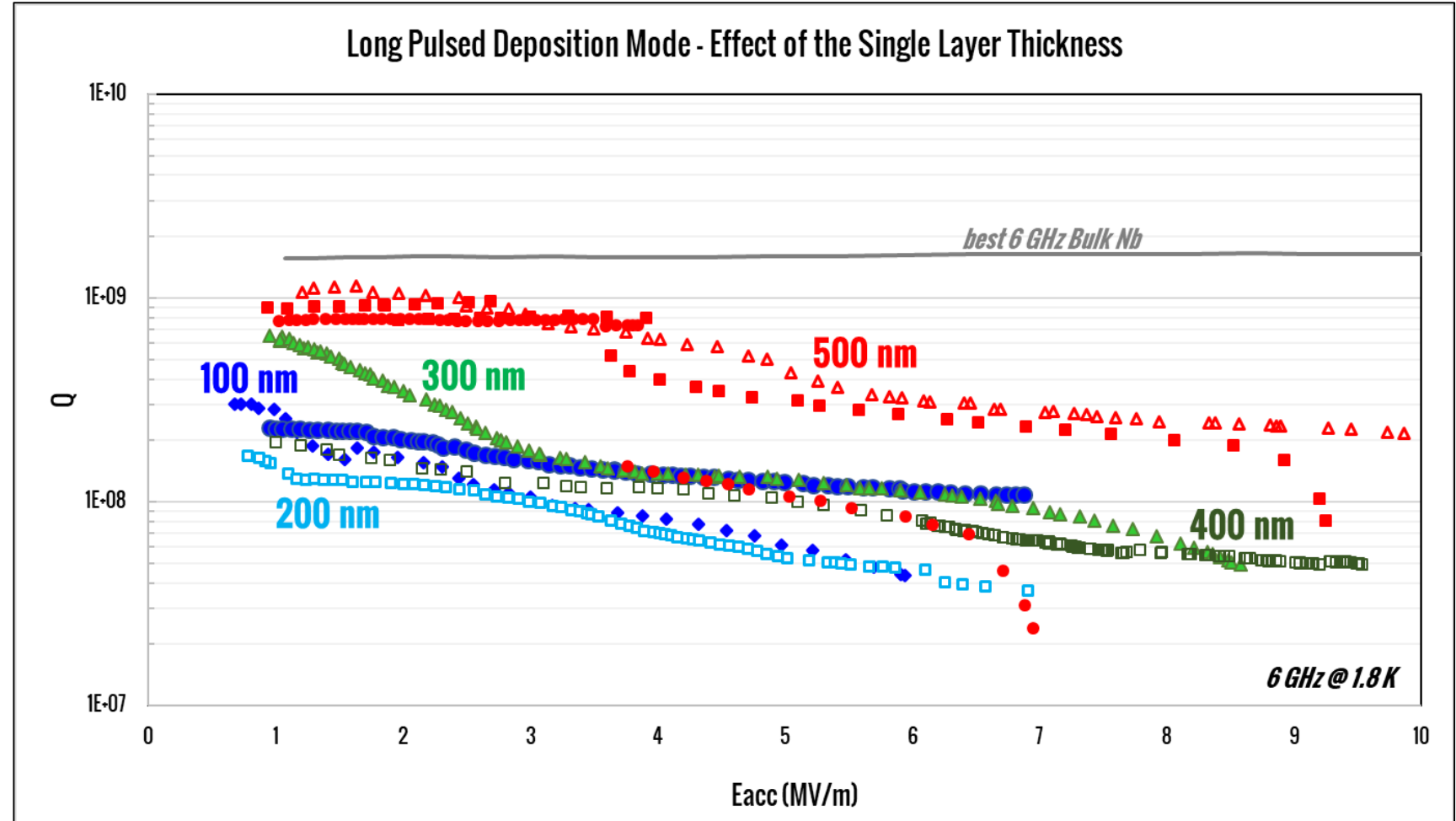
Single Layer Thickness effect



Single Layer Thickness



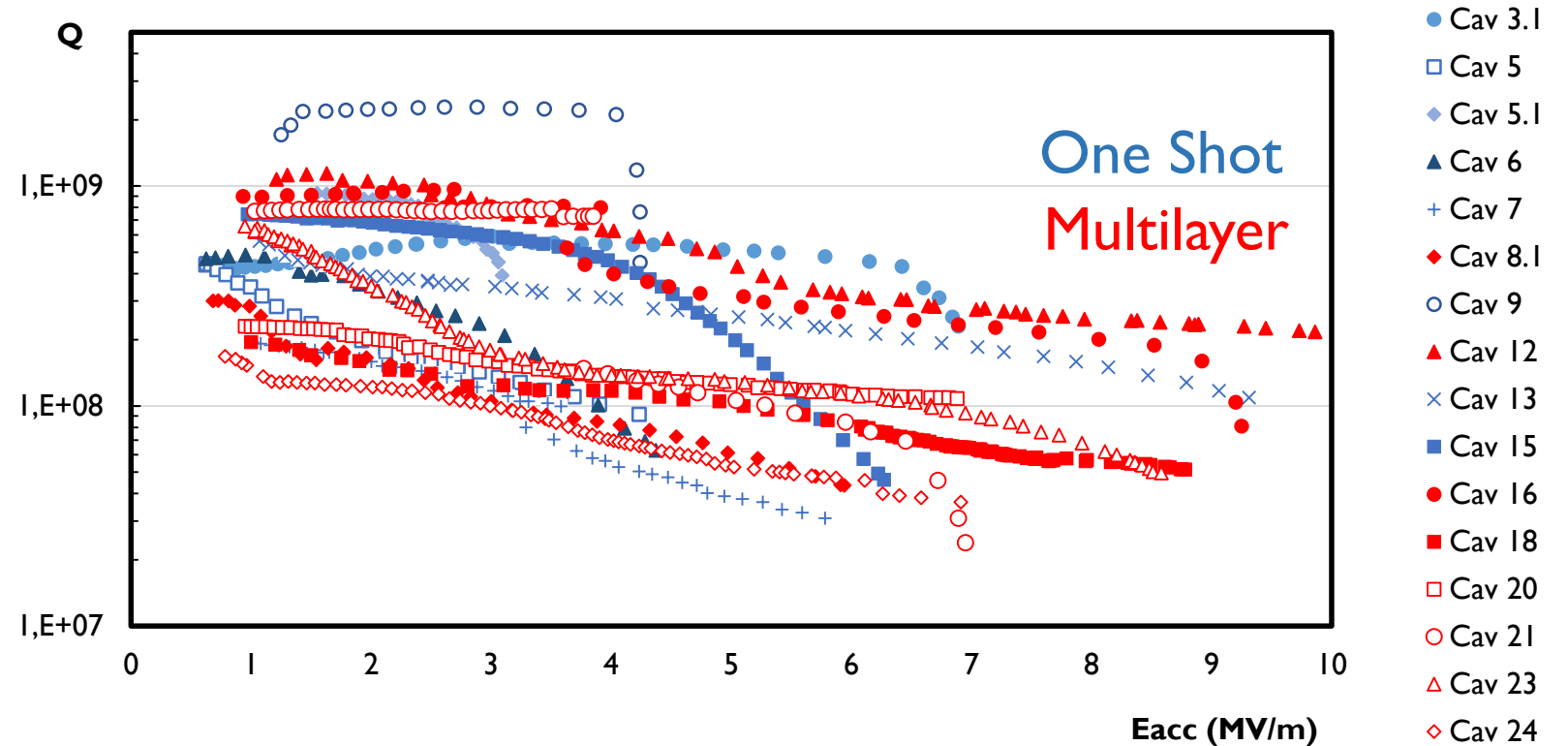
Total Thickness



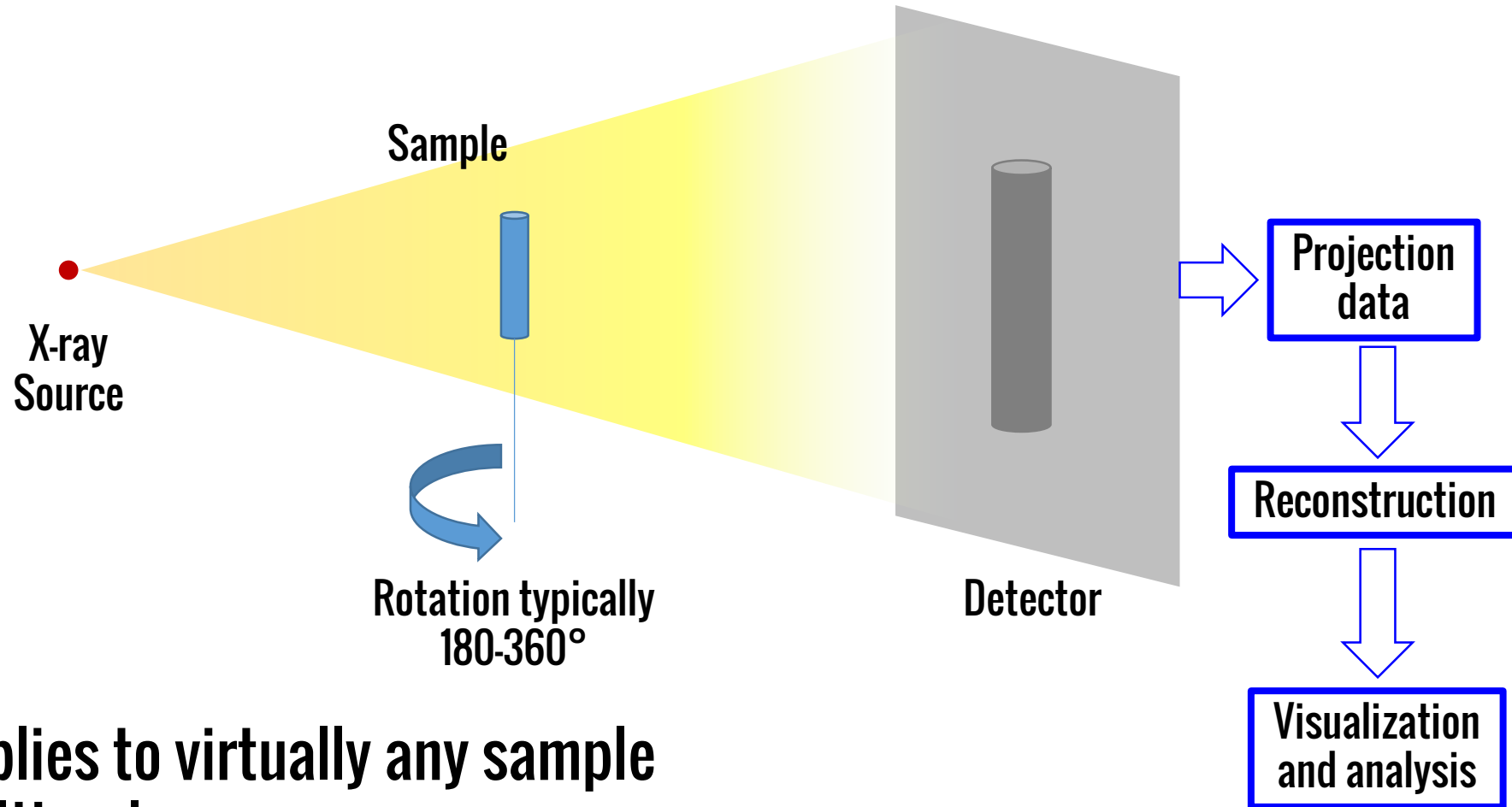
How to avoid peeling/increase film quality? (3)

LONG PULSE DEPOSITION MODE

- reduce **peeling risk**
- may contribute to **increase E_{acc}**



X-ray Computed Tomography



- 3D
- Applies to virtually any sample
- Multiscale
- Non-destructive

X-ray Computed Tomography

